

科环2012



电磁兼容原理与应用整改 EMC & its Deisgn

报告人：和军平 (Dr.)

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Shenzhen City

hejunping@hitsz.edu.cn



内 容

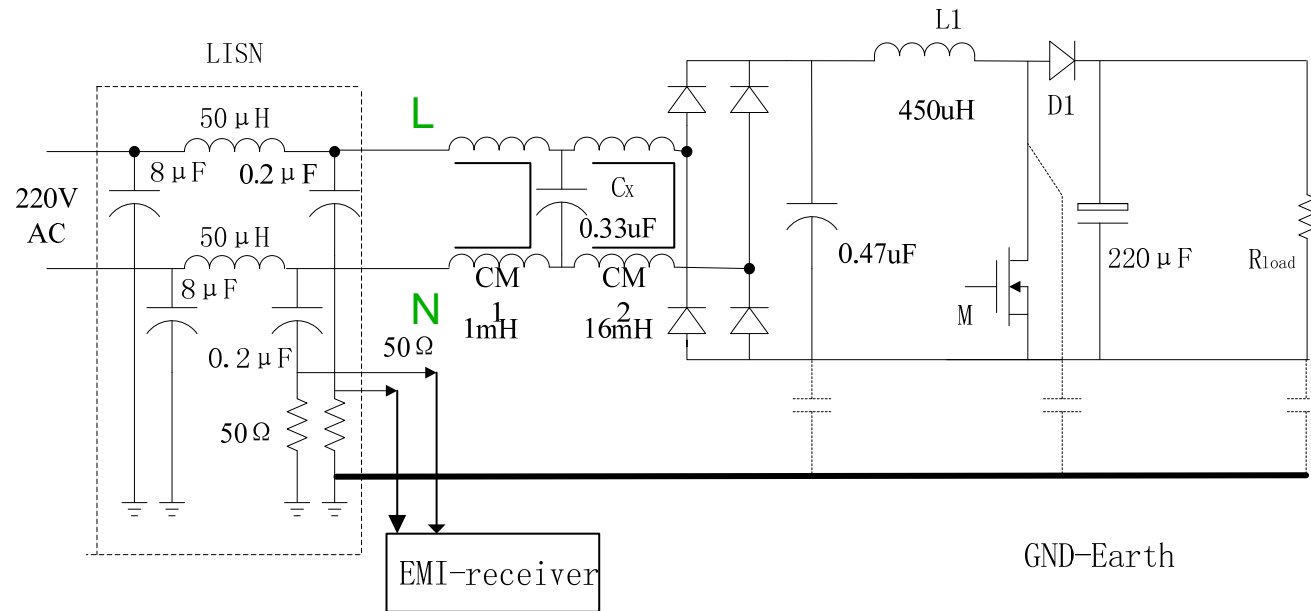
- 一. 开关电源干扰形成机理
- 二. 无源EMI滤波器设计
- 三. 新型EMI抑制技术
- 四. 滤波器的特殊问题

一：电力电子装置的传导电磁干扰发射(150kHz-30MHz)

1.1 电力电子装置传导干扰发射基本原理

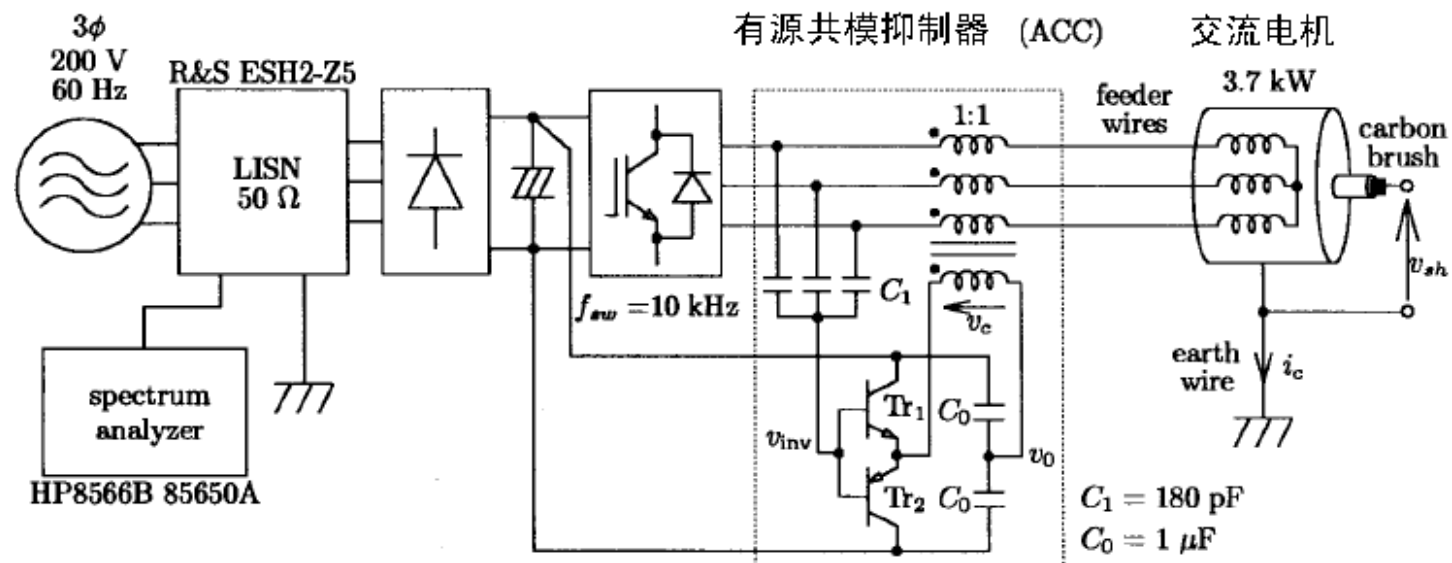
1.1.1：测试布局 and 检测量

单相：L, N line



EMI接收机测量上述线上的射频干扰量值，均要小于限值

三相: L1, L2, L3, Earth

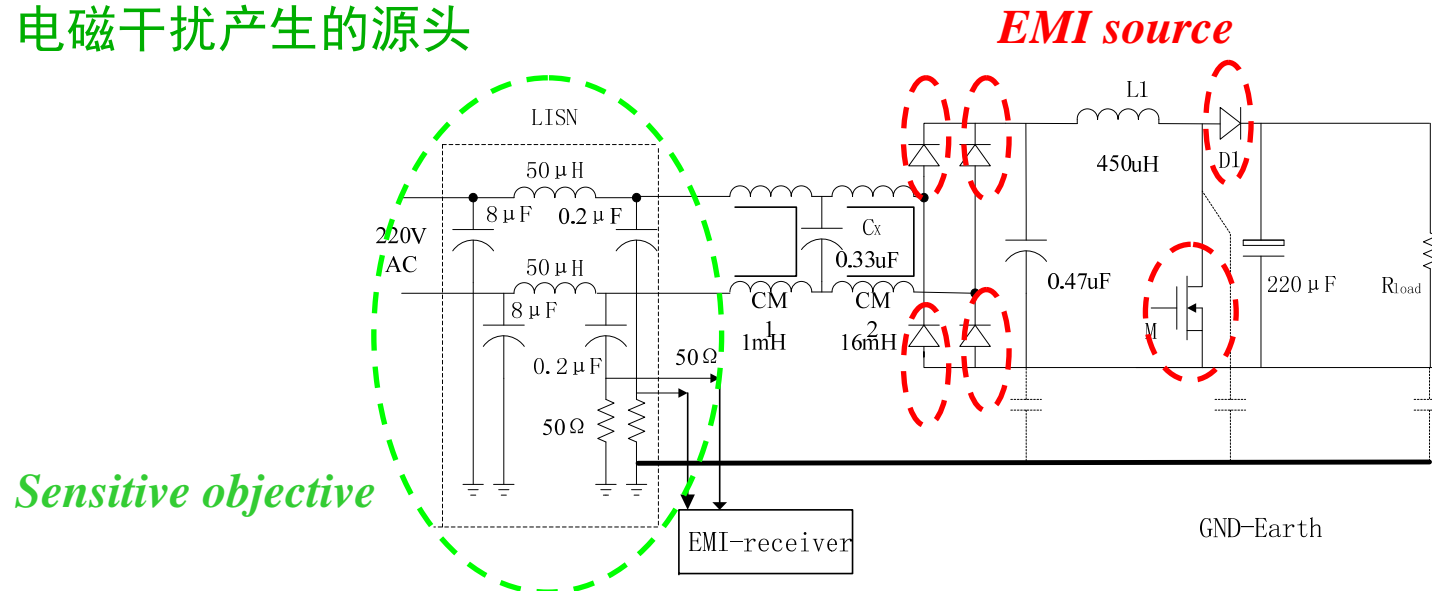


EMI接收机测量上述线上的射频干扰量值，均要小于限值

1.1.2 电力电子装置电磁干扰的产生源头和传播机理

Three factors of EMI! EMI source, coupling paths, sensitive objective

电磁干扰产生的源头



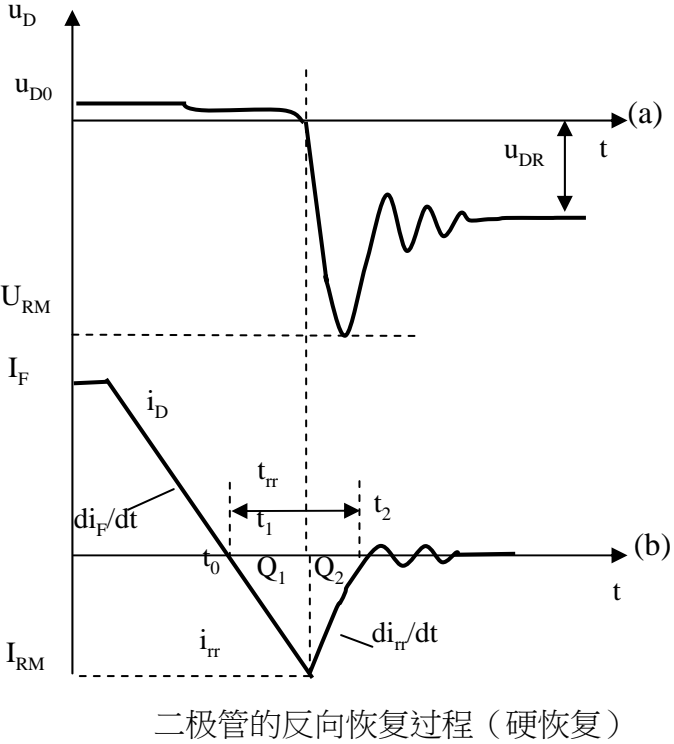
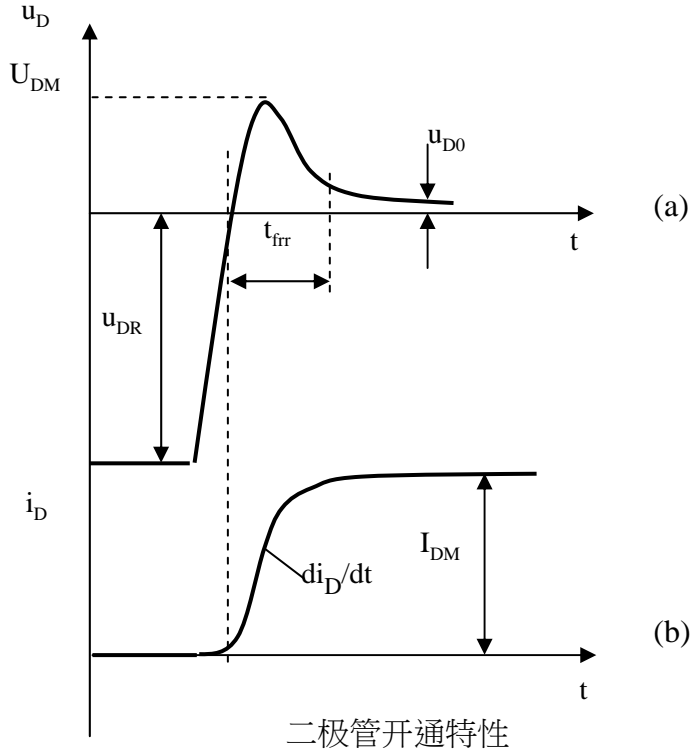
*There are lots of different opinions. Mosfet, Diode, transformer, AC loop etc
Strictly speaking,*

Only Nonlinear switching devices are true EMI sources for EMI emission!

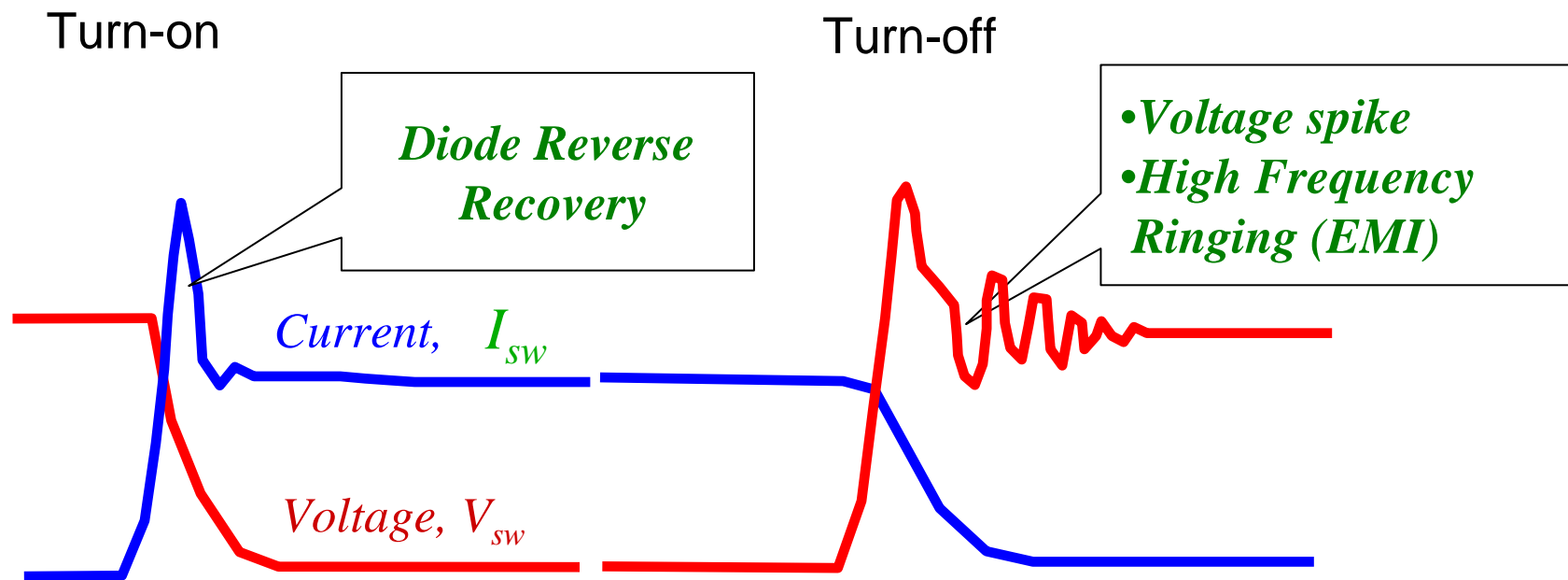
Others are coupling paths!

Only for Radiation emission or simply analysis, others transformer and AC loop can be treated as EMI source!

A: Diode turn-on and turn-off



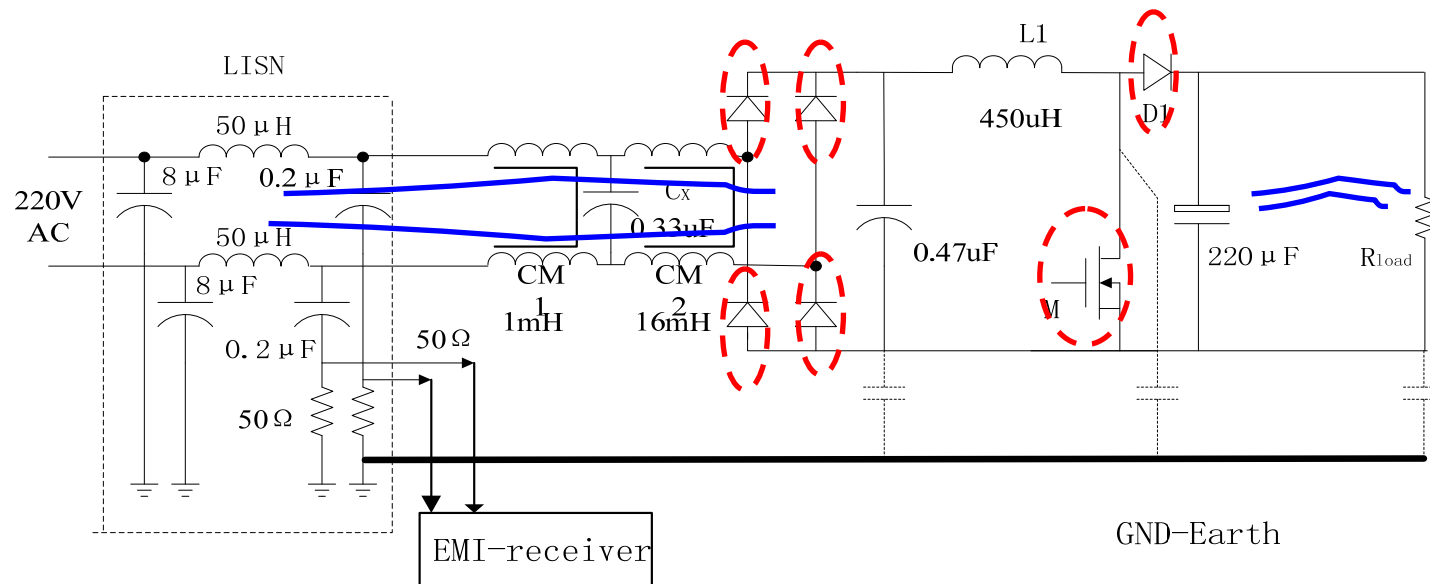
B: Transistor turn-on and turn-off



How about coupling paths! The difficult factors!

Basic EMI coupling mechanism

A: Along metal Lead



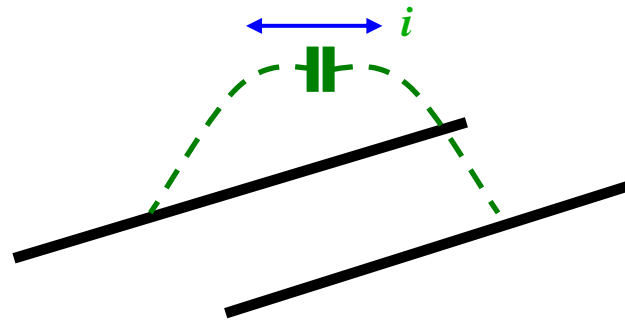
Basic EMI coupling mechanism

B: space Induct effect

B1: Capacitive coupling effect:

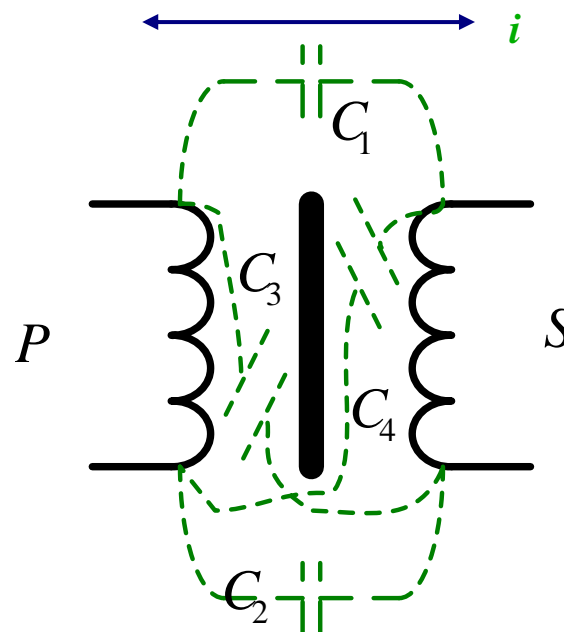
There is a coupling capacitor between every-two conductors!

Trace



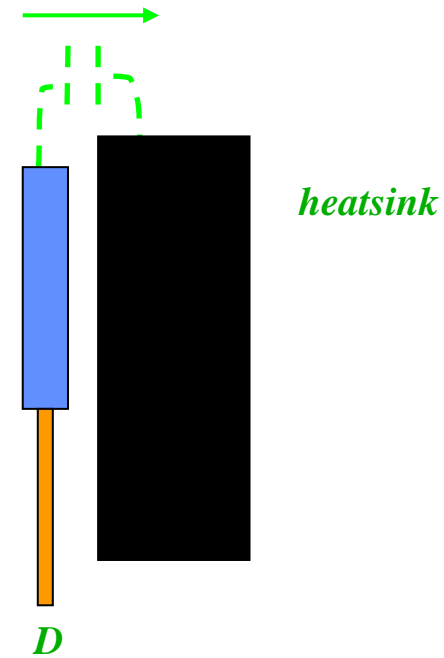
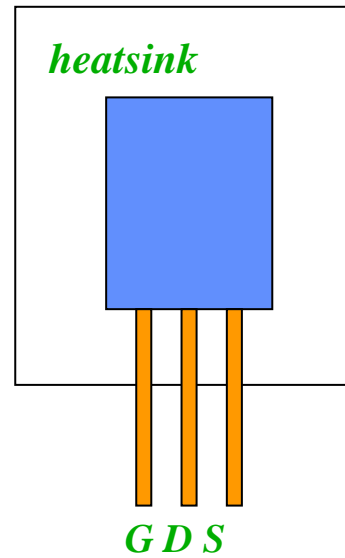
$$C_{12} = k \frac{S_1 S_2}{D}$$

Transformer

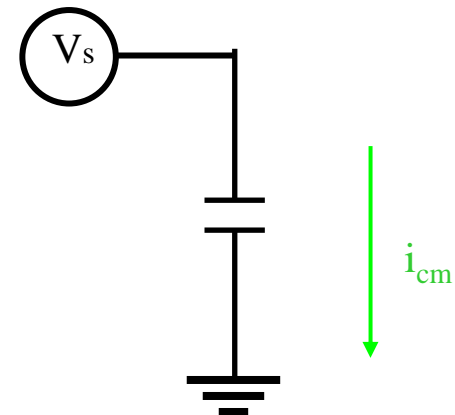
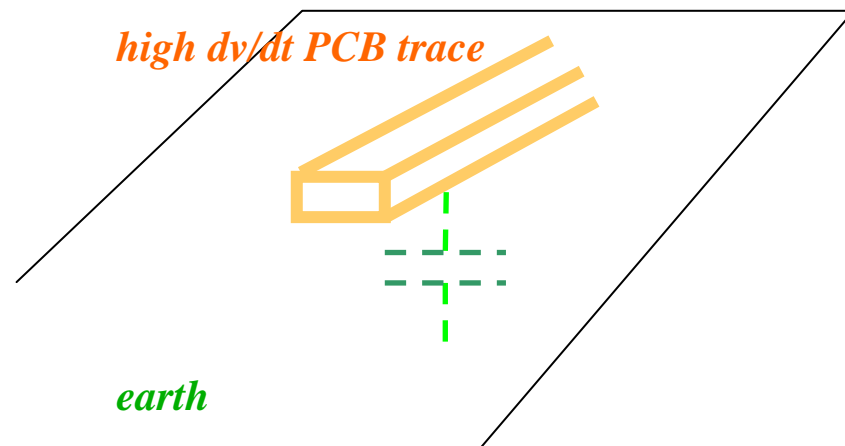


B1: Capacitive coupling effect:

Capacitor between drain to heatsink



Capacitor between high dv/dt trace or metal to earth

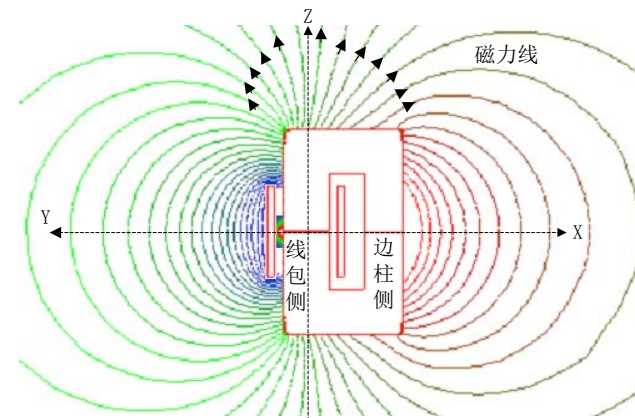
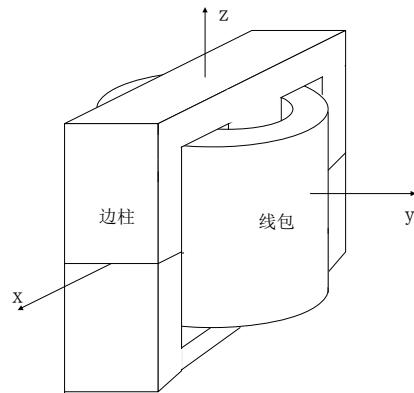


B2: Inductive coupling effect:

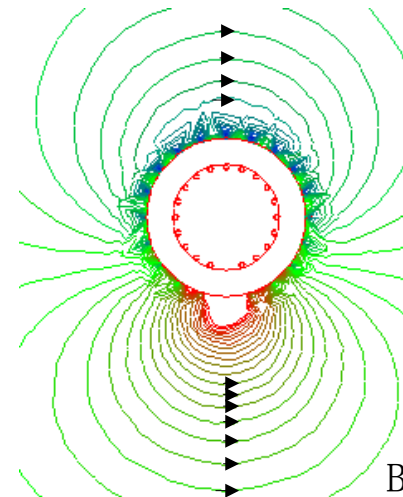
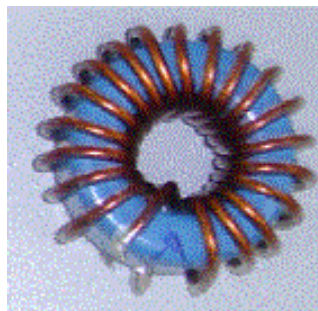
There is a coupling inductor between every-two loops!

Typical magnetic loops:

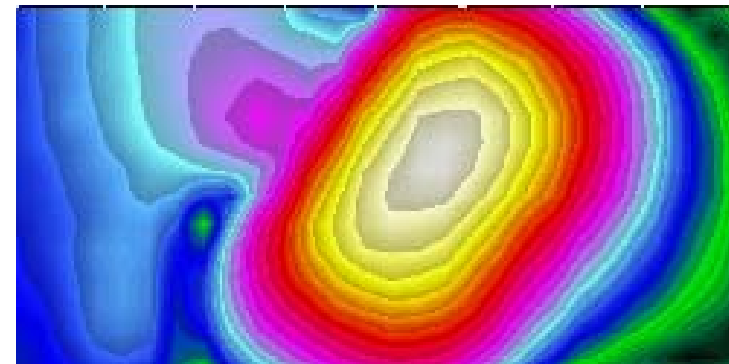
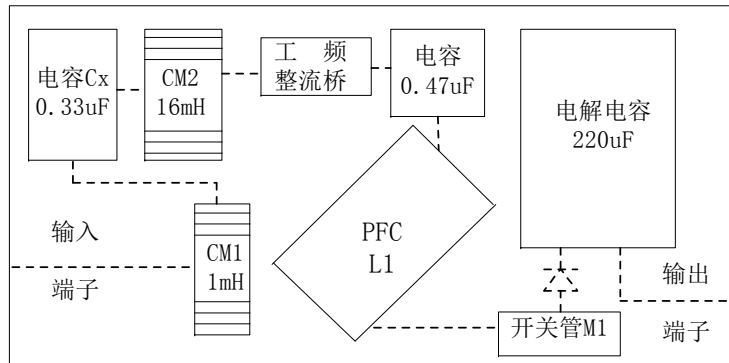
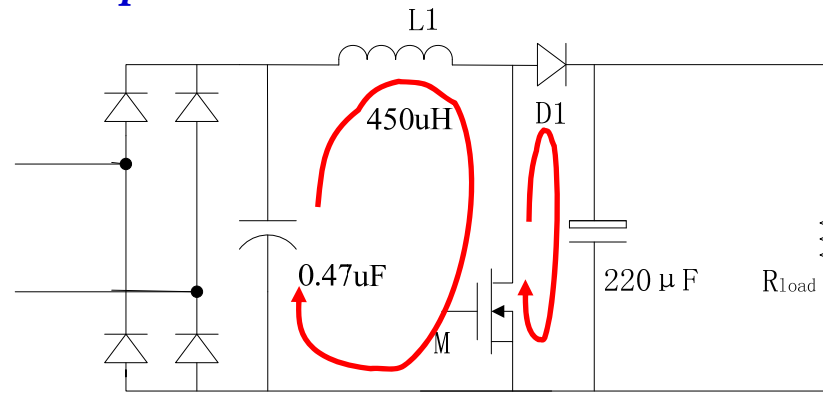
Inductor1: Transformer:



Inductor2:



High frequency AC loops

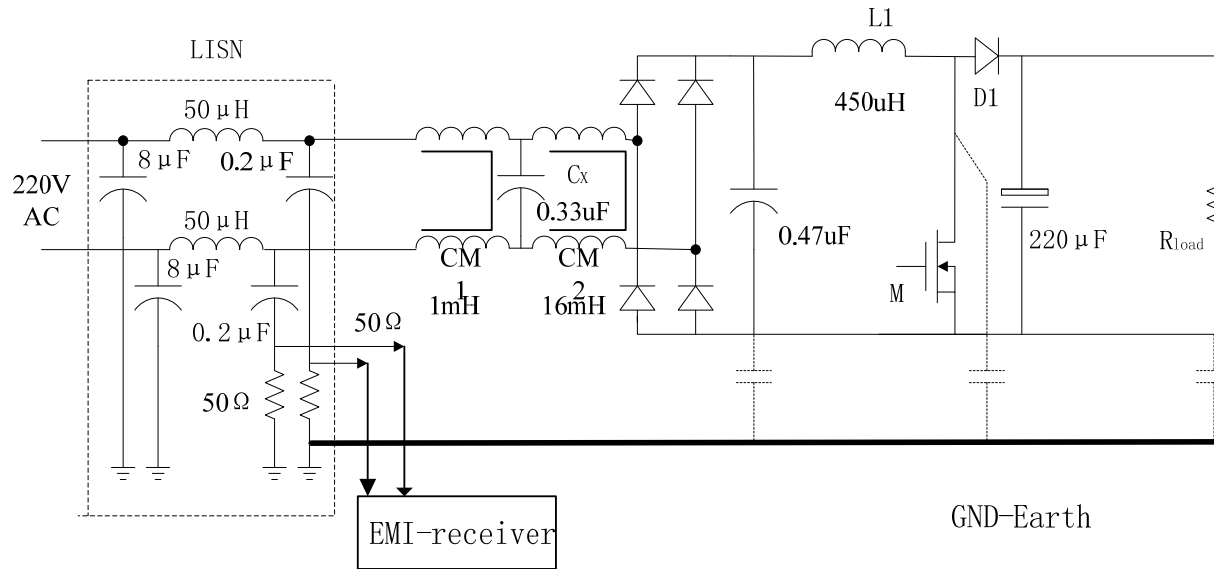


Inductive coupling: produce EMI directly some time → sensitive circuit
 complicit EMI coupling paths. → influence EMI filter performance.

1.1.3 电力电子装置电磁干扰的共模/差模分析

Why?

Example: Single phase



Emission on L line: V_L

Emission on N line: V_N

$$V_{CM} = (V_L + V_N) / 2$$

$$V_{DM} = (V_L - V_N)$$

V_{cm} & V_{dm}

$$V_L = V_{CM} + V_{DM} / 2$$

$$V_N = V_{CM} - V_{DM} / 2$$

So, V_L & V_N V_{cm} & V_{dm} are same!

Why? 因为差模回路和共模回路有不同的特点和性质，分开考虑，便于把握EMI形成、传播和抑制。

差模回路： voltage or current between L&N or among L1、 L2、 L3

Equivalent internal impedance is small! Paths is clear!

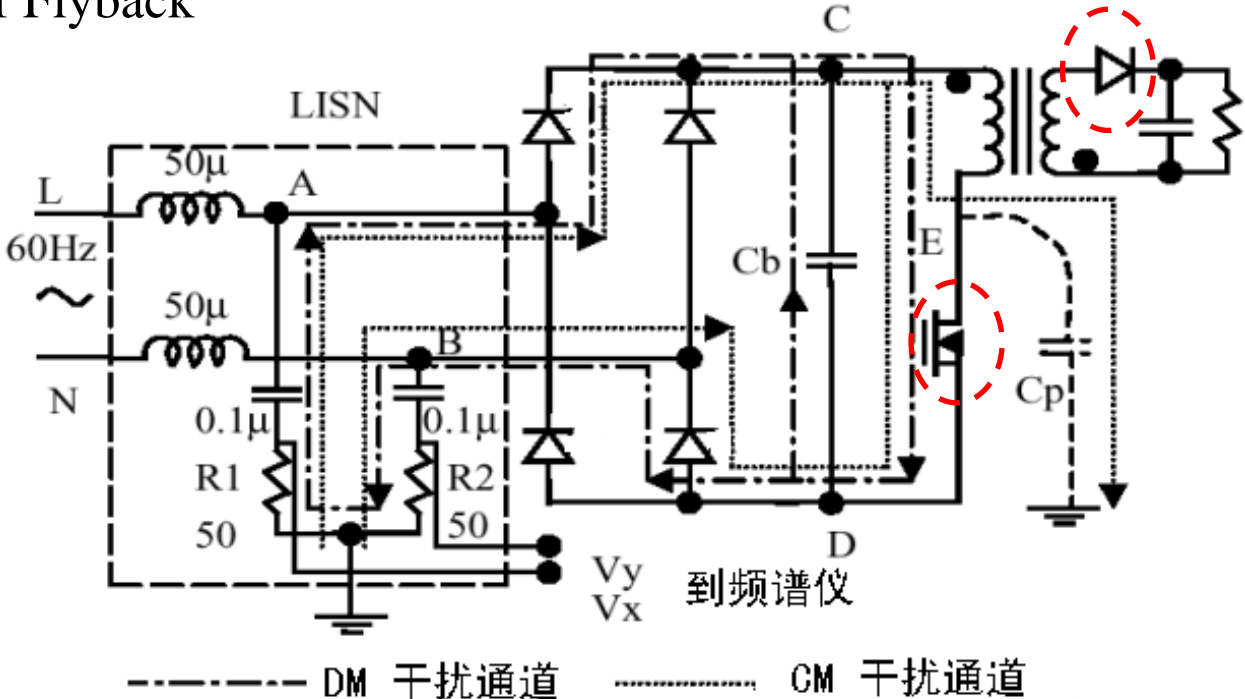
Through lines-load

共模回路： voltage or current between lines and Earth

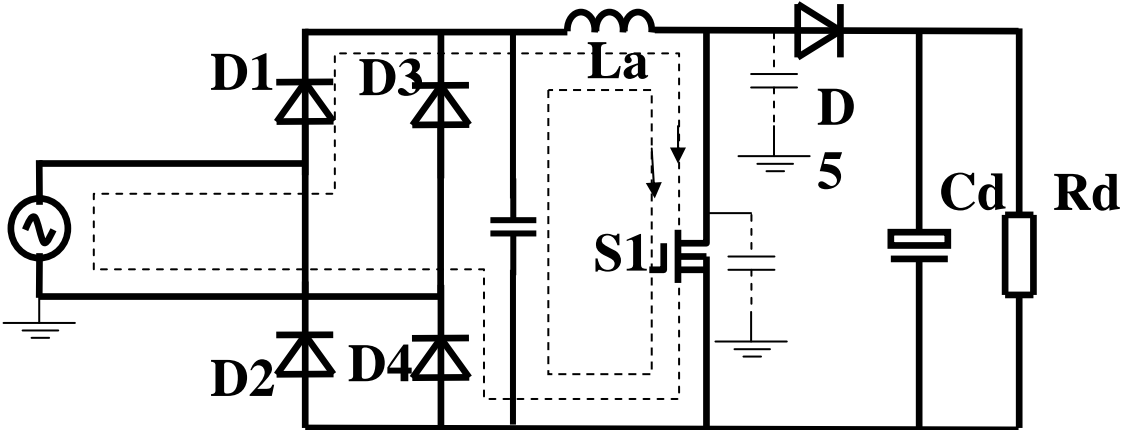
Equivalent internal impedance is large! Paths is unclear in most case!

Through parasitic capacitor

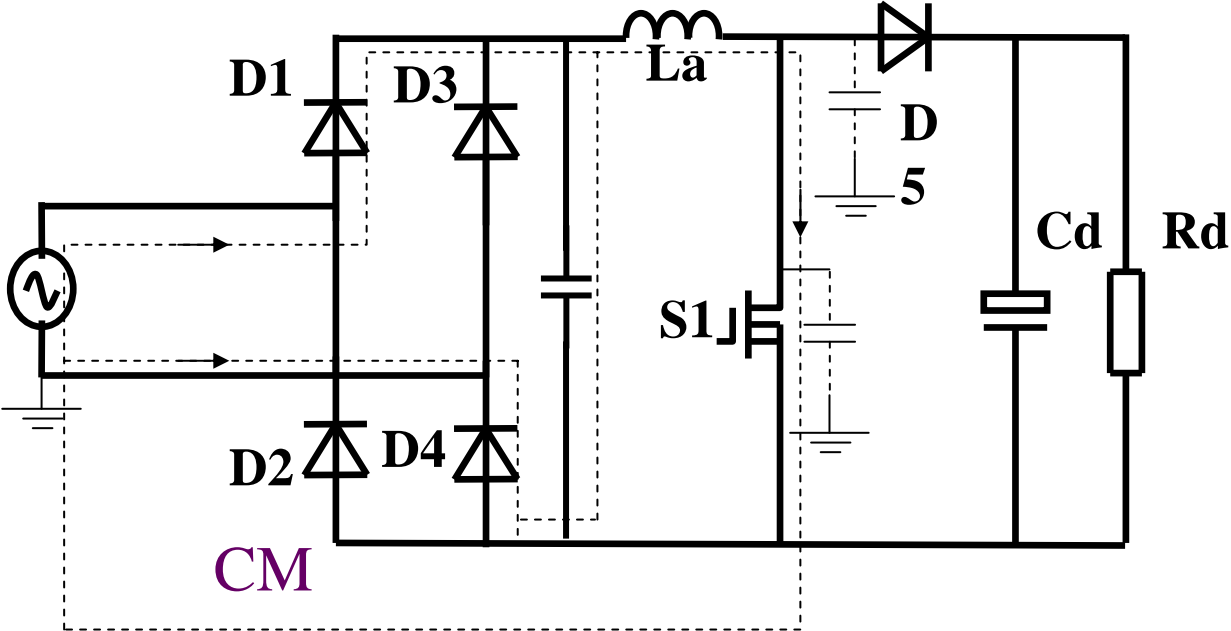
Example1 of Flyback



Example2 of a Boost PFC

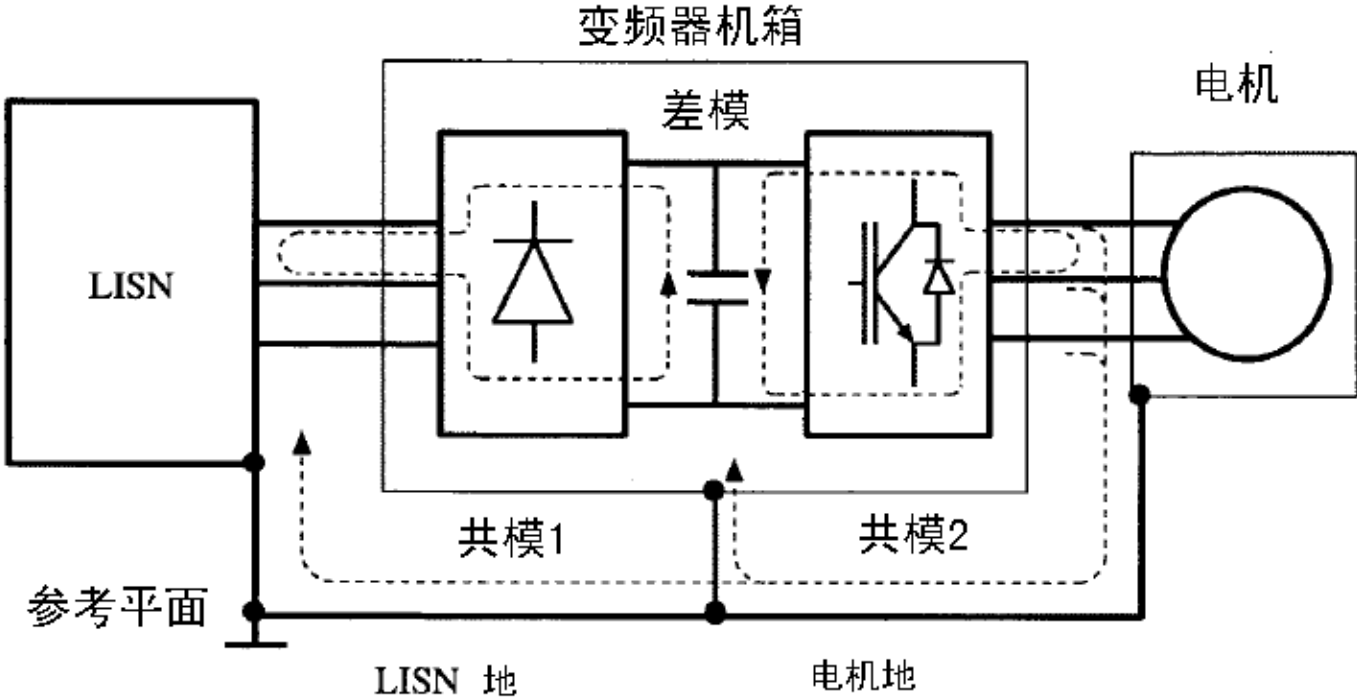


Noise Path of DM Noise without LISN



Noise Path of CM Noise without LISN

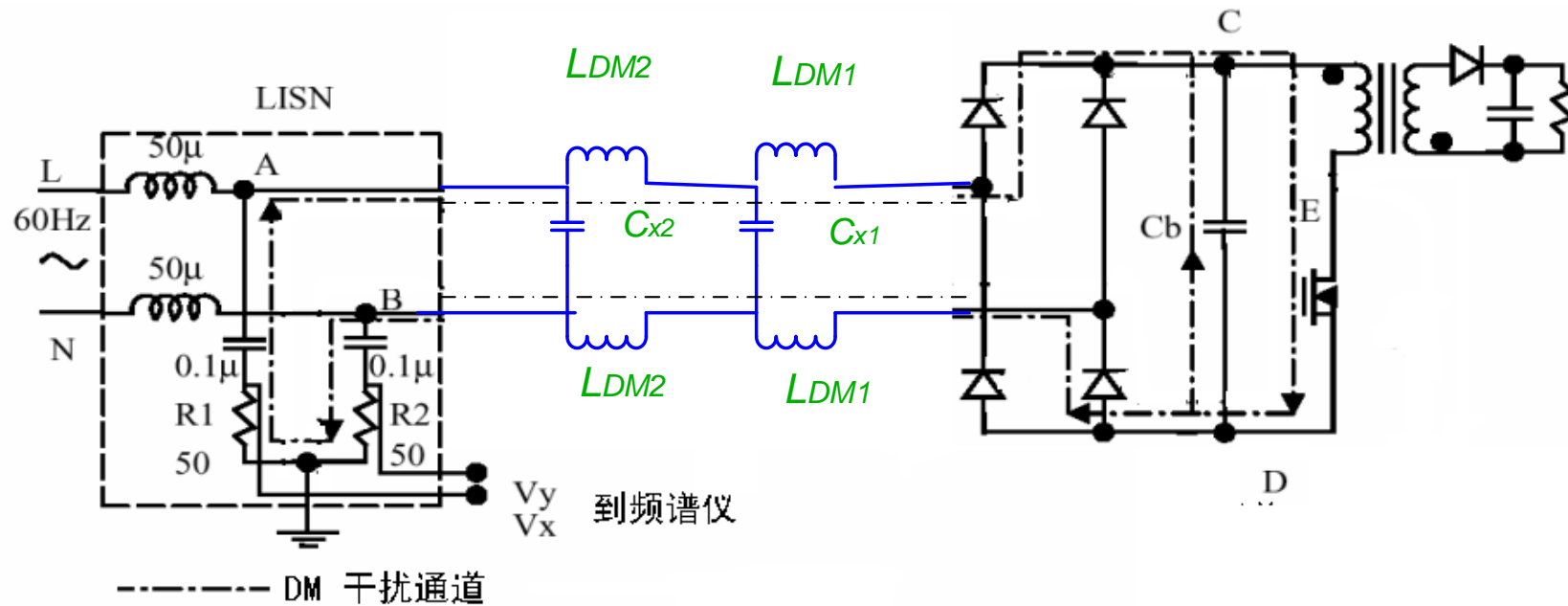
Example3 of a INVERTER



Usefulness of DM/CM Analysis:

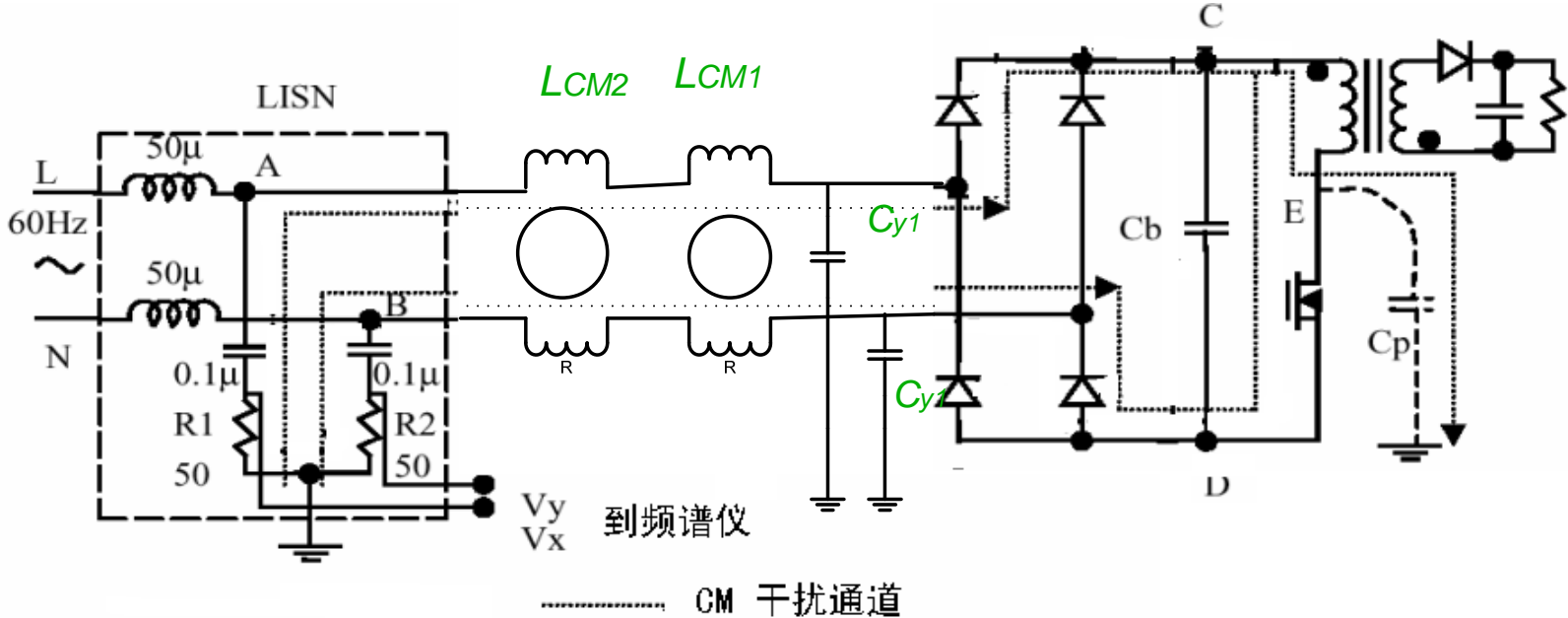
It is very useful for EMI filter design and EMI debug!

DM EMI filter to control DM emission! It has no influence on CM EMI.



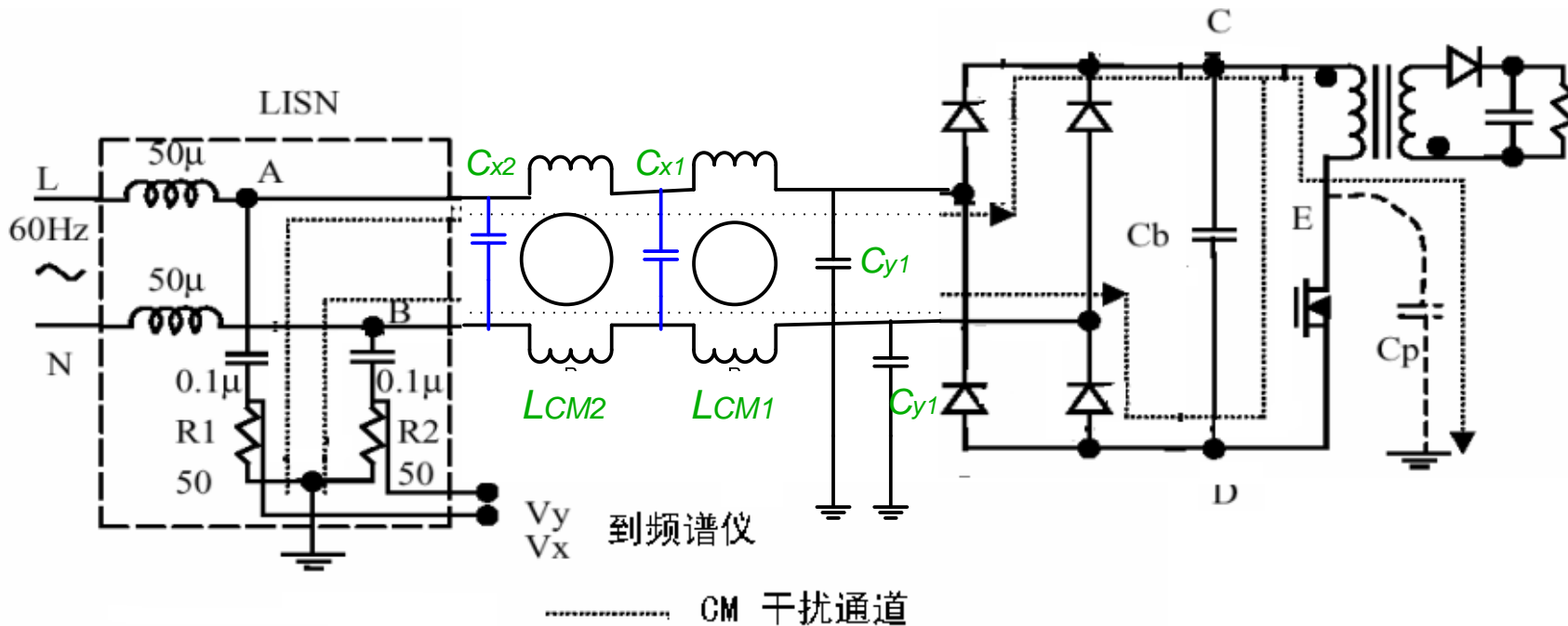
Generally, Cx is large several uF, Ldm is small!

CM EMI filter to control CM emission! It has no influence on DM EMI.



An actual EMI filter to control EMI emission!

CM filter+DM filter

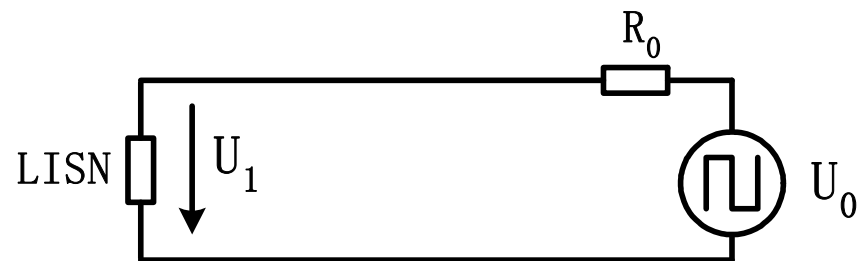


The leakage inductance of CM choke can be used as LDM

二 电力电子装置EMI滤波器抑制技术

2. 1 EMI滤波器的设计和使用

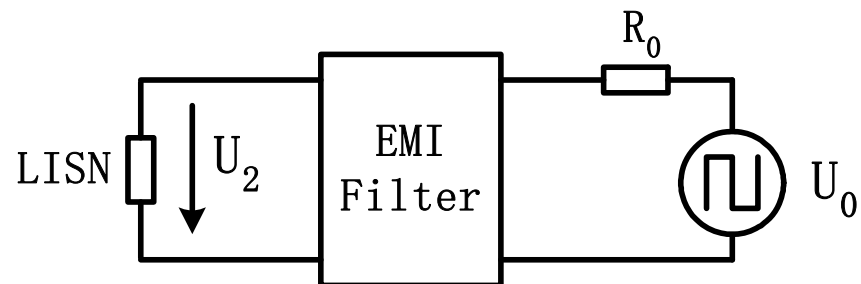
Insertion Loss Definition



U₀: Noise Source

R₀: Noise Source Impedance

U₁: Voltage on LISN when without Filter



U₂: Voltage on LISN when with Filter

$$IL = 20 \text{Log} \left(\frac{U_1}{U_2} \right)$$

A: How to select the best EMI filter topology?

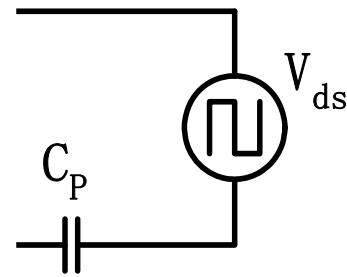
$Z_g \backslash Z_1$	High	Low
High		
Low		

Z_g : Noise Impedance

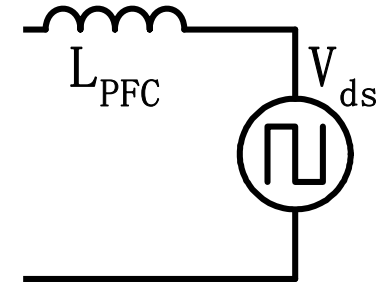
Z_1 : LISN Impedance

If one stage is not enough, several stages filter can be used!

Power supply EMI can be separated into equivalent CM/DM EMI source model.

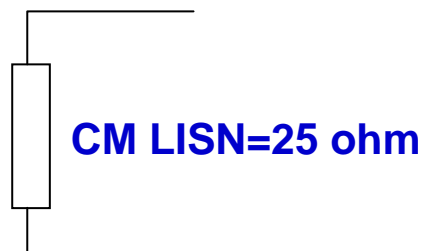


CM source

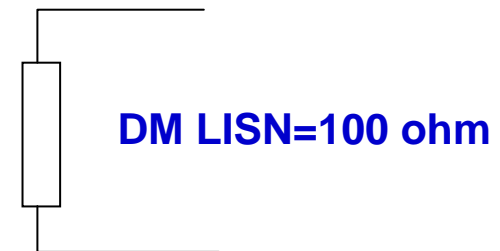


DM source

Generally—internal DM source impedance is small!
internal CM source impedance are large!



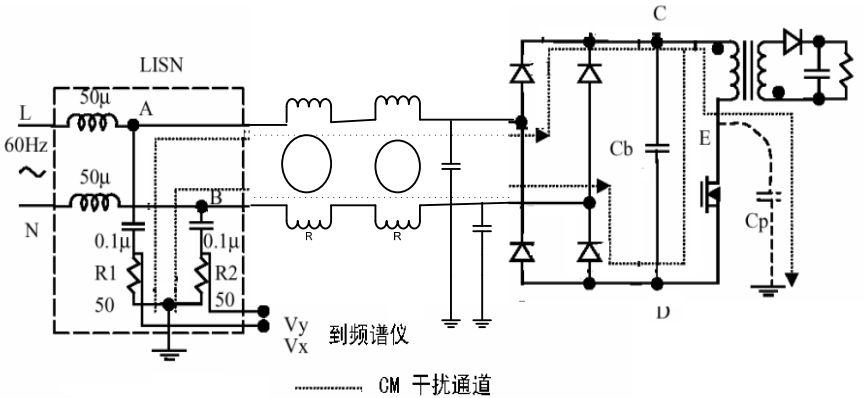
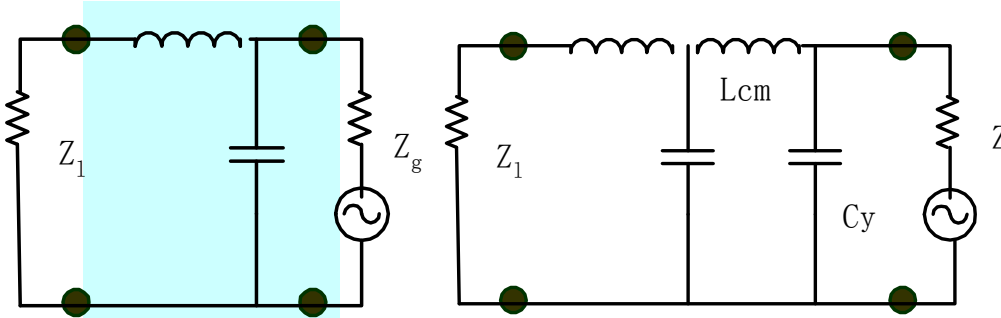
CM LISN=25 ohm



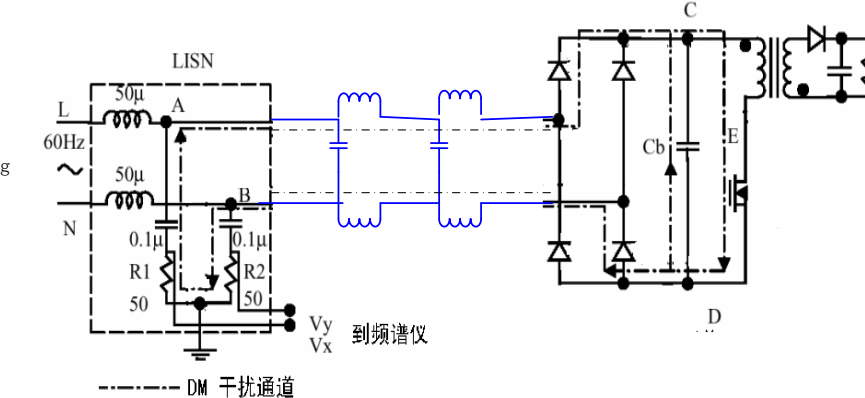
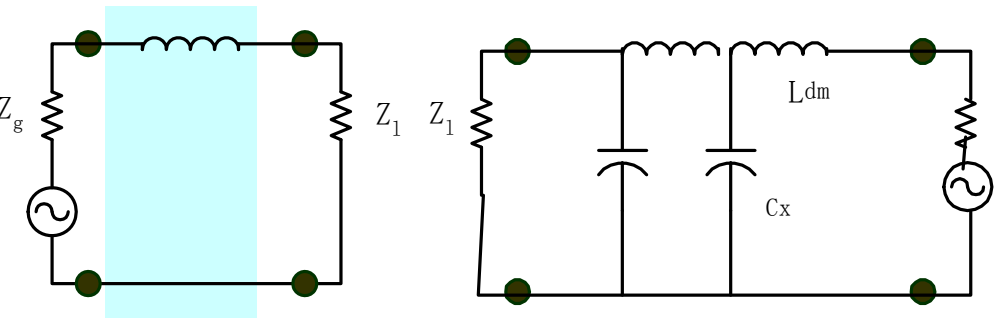
DM LISN=100 ohm

Generally—Both LISN DM impedance and CM impedance are small!

So, better CM filter topology



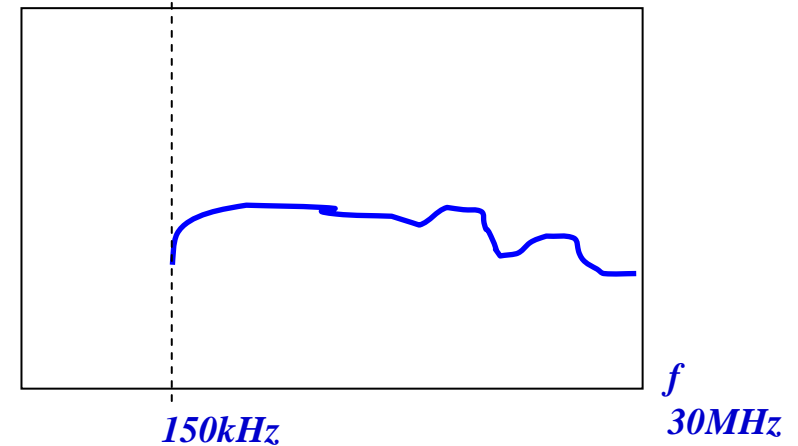
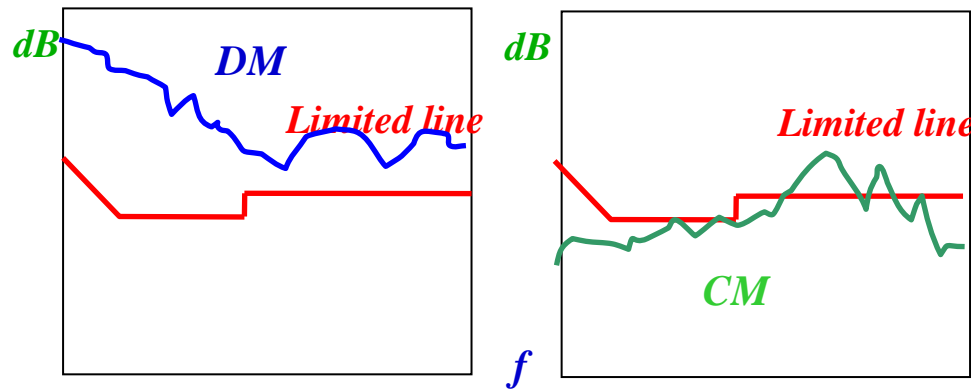
So, better DM filter topology



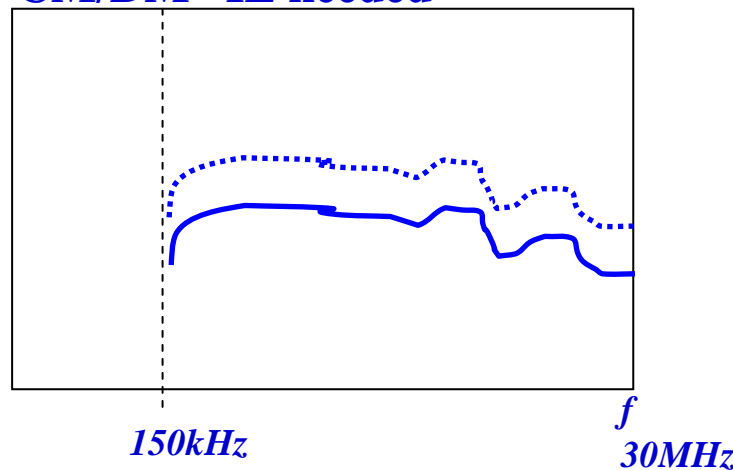
B: How to decide inductance, capacitance value of EMI filter topology?

Step1: Separate CM/DM emission using test or simulation results!

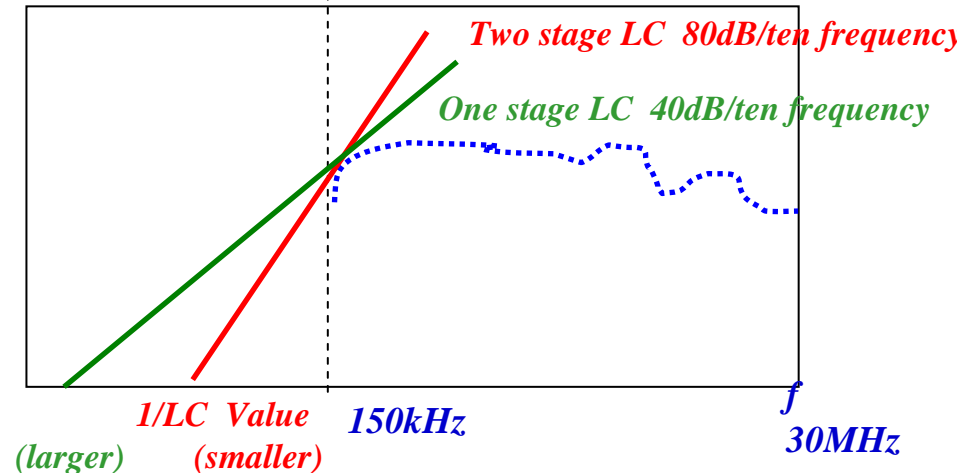
Step2: Using CM/DM emission decrease limited line, the IL needed of filter are gotten.



Step3: adding 10 dB margin for both CM/DM IL needed



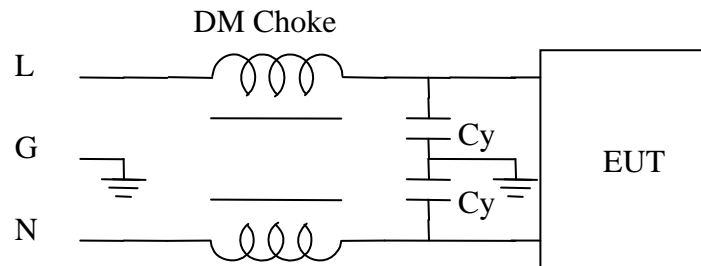
Step4: According LC number, draw N*40dB line which is tangential to dot IL line.



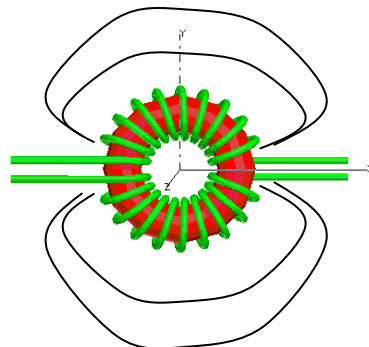
Step5: LC value, consider other factor, we can decide L and C.

For CM, the max C_y value is limited by leakage current, so $L_{cm}=f_0/C_y$.

L_{cm} is called **CM choke** too.

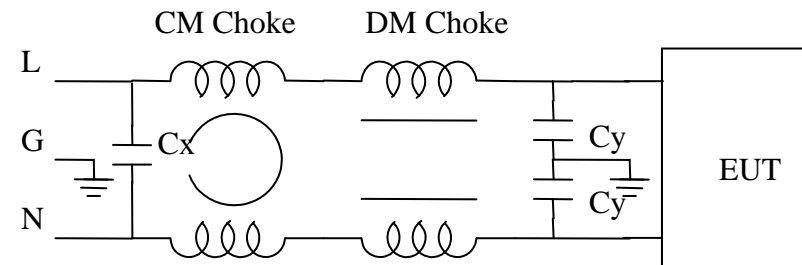


For DM, for C_x can be easy large enough, L_{dm} is select small. In most case L_{dm} can be replaced by the leakage inductor od CM choke.



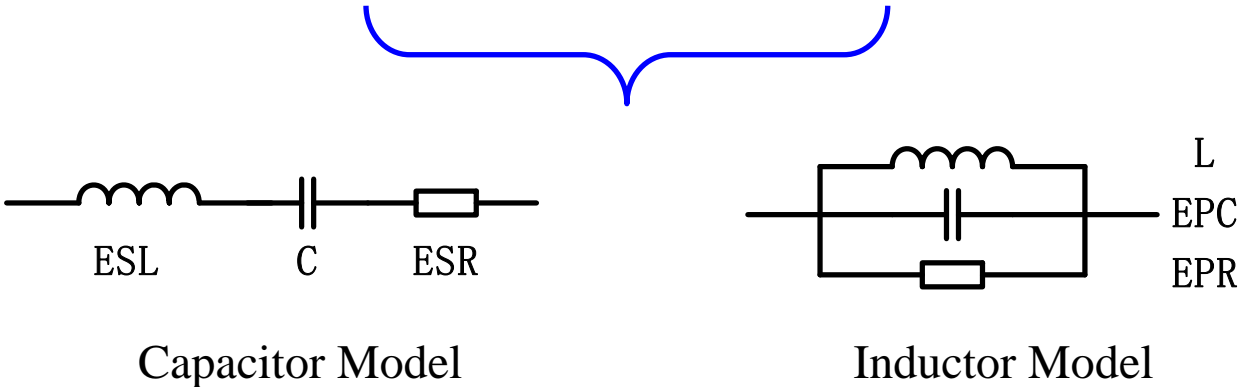
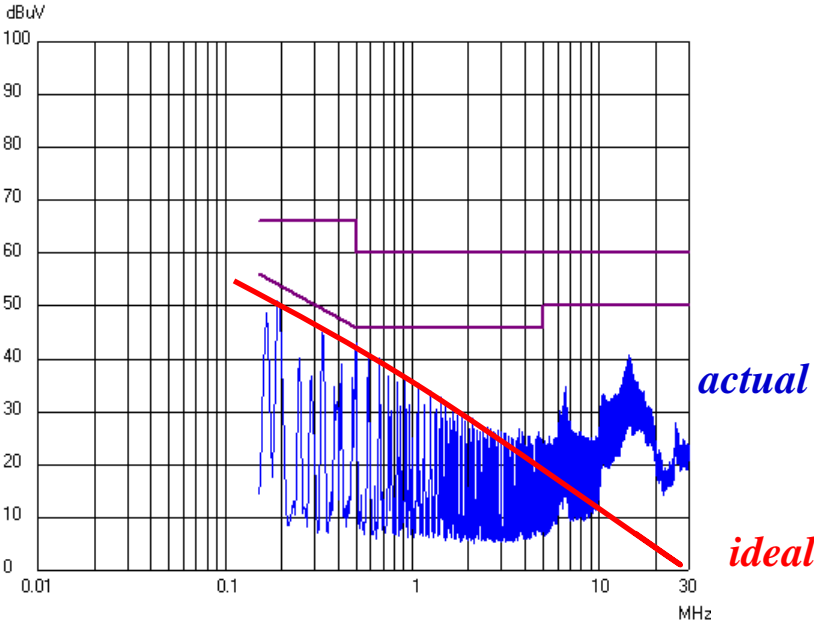
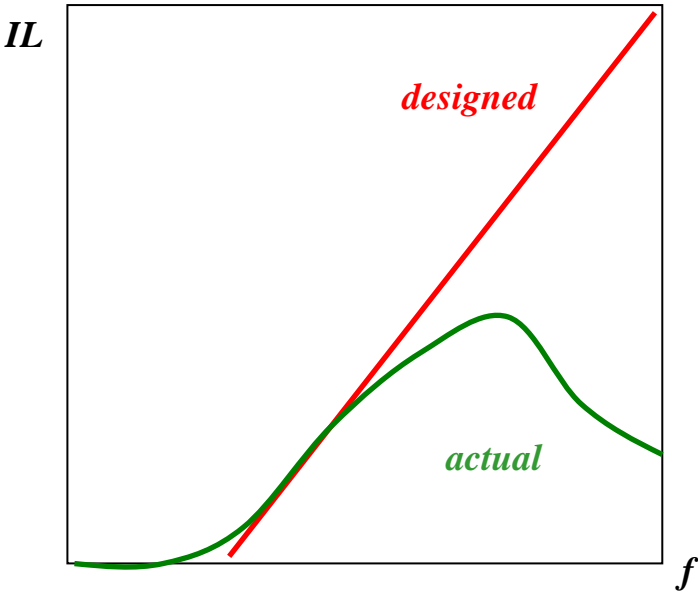
leakage inductor

Step6: finish design and test.



C: Actual problem during EMI filter use

1: HF IL are lower than expected.

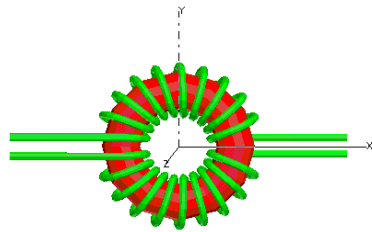


What to do?

Decrease parasitic as possible!

1: Using good HF capacitor or inductor! Small parasitic parameter!

对于电感:



铁氧体: 易饱和、导磁率高, 常用作共模扼流圈的磁芯

锰锌: $\mu_r = 500 \sim 10000$ for lower frequency CM choke

镍锌: $\mu_r = 10 \sim 100$ fit for HF CM choke

采用少匝, 交错绕制等办法减小线圈的EPC!

非晶，纳米晶磁芯

特点：类似于锰锌铁氧体、高u, 高Bs, LF

用途：电感、变压器，LF CM choke

铁基非晶

饱和磁感应强度Bs	1.25 T	饱和磁致伸缩系数	2×10^{-6}
居里温度Tc	560 °C	密度d	7.2 g/cm ³
晶化温度Tx	510 °C	电阻率	130μΩ·cm
硬度Hv	880kg/mm ²	热膨胀系数	

产品牌号	R-N-L	R-N-M
初始导磁率	$>3 \times 10^4$	$>8 \times 10^4$
最大导磁率	$>5 \times 10^4$	$>45 \times 10^4$

铁基纳米晶

饱和磁感应强度Bs	1.25 T	饱和磁致伸缩系数	2×10^{-6}
居里温度Tc	560 °C	密度d	7.2 g/cm ³

产品牌号	R-N-L	R-N-M	R-N-H
初始导磁率	$>3 \times 10^4$	$>8 \times 10^4$	$>1 \times 10^4$
最大导磁率	$>5 \times 10^4$	$>45 \times 10^4$	$>50 \times 10^4$

钴基非晶

产品牌号	R-N-L	R-N-M
初始导磁率	$>3 \times 10^4$	$>8 \times 10^4$
最大导磁率	$>5 \times 10^4$	$>45 \times 10^4$

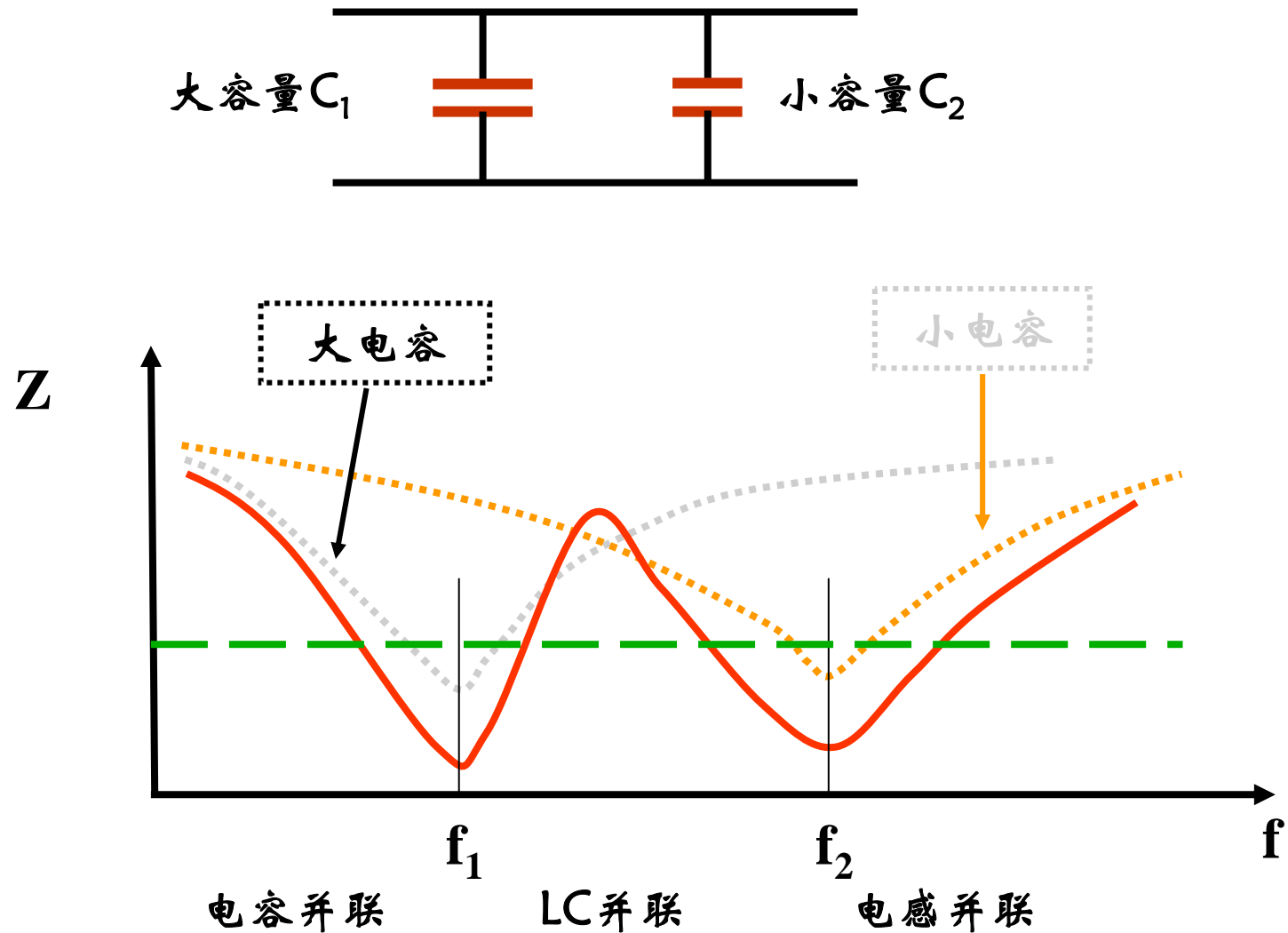
饱和磁感应强度Bs	1.25 T	饱和磁致伸缩系数	2×10^{-6}
居里温度Tc	560 °C	密度d	7.2 g/cm ³
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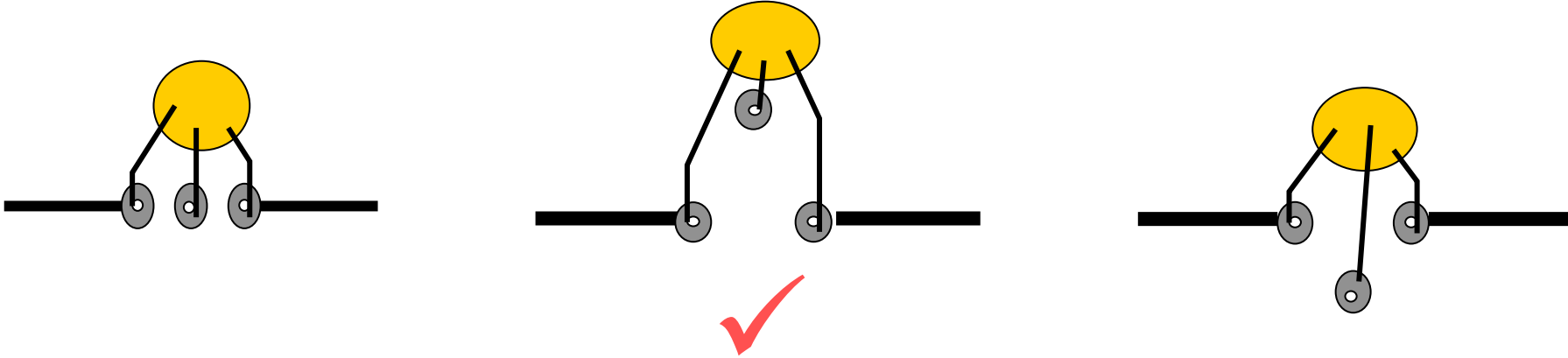
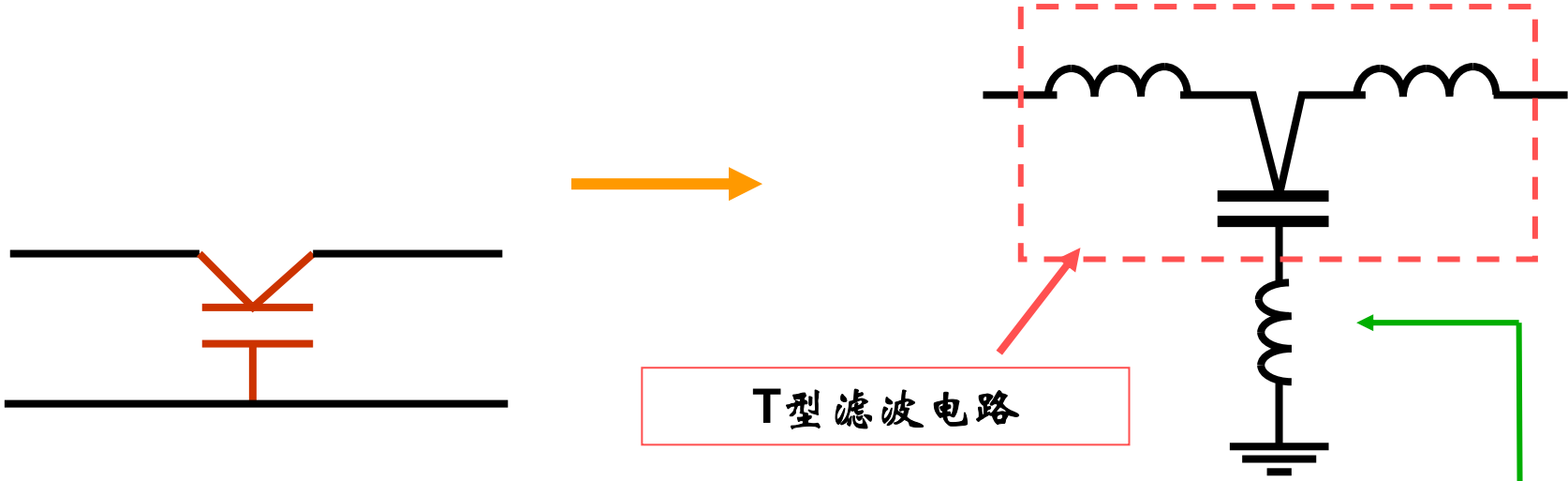
安泰

对于电容:

1: 采用高频性能好的小电容。

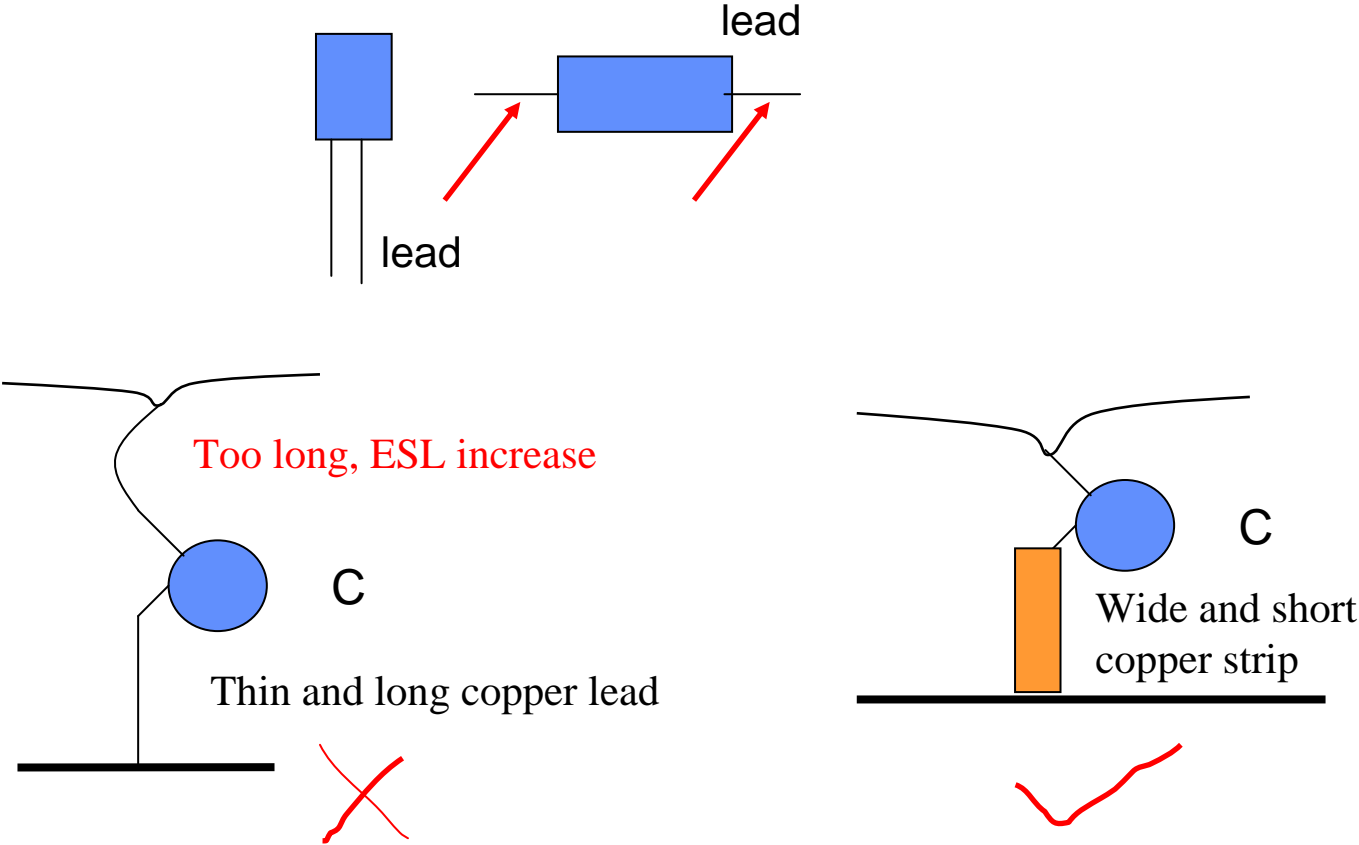


使用三端电容器

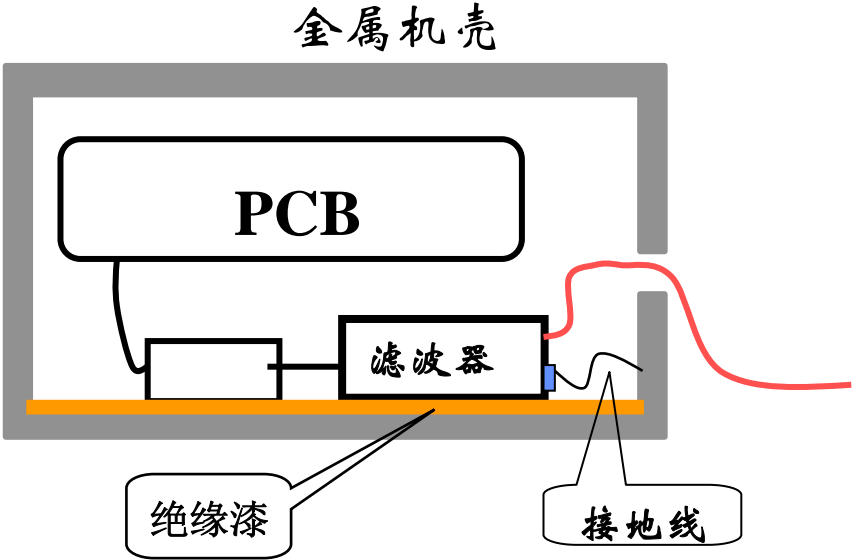
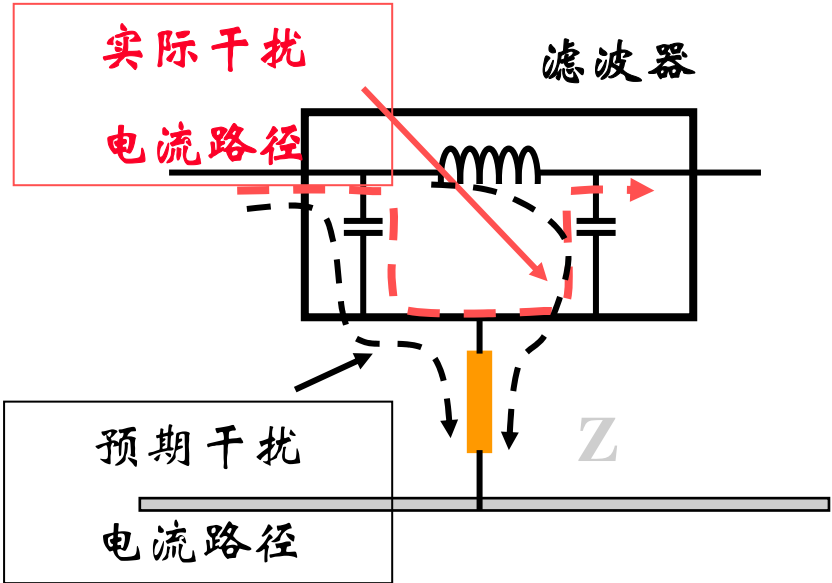


一些新型结构电容, x2y,

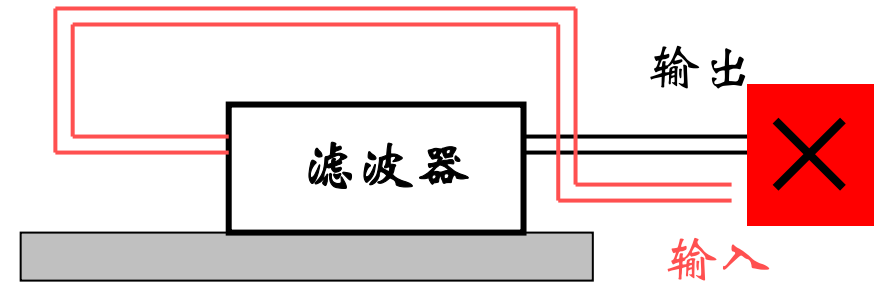
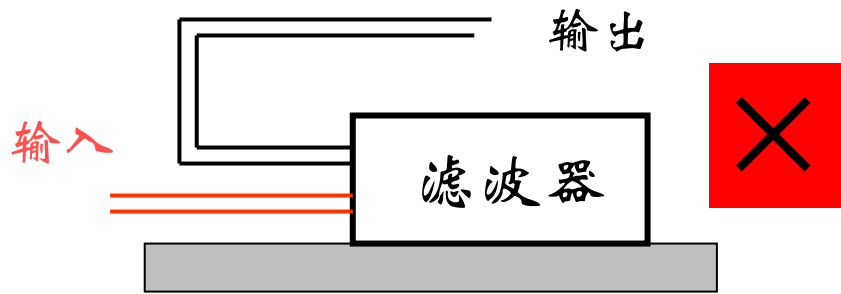
2: Decrease lead length of capacitor as shorter as possible. ESL!



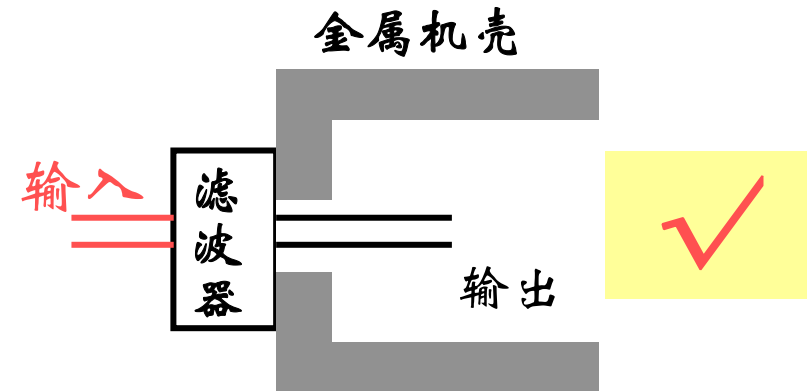
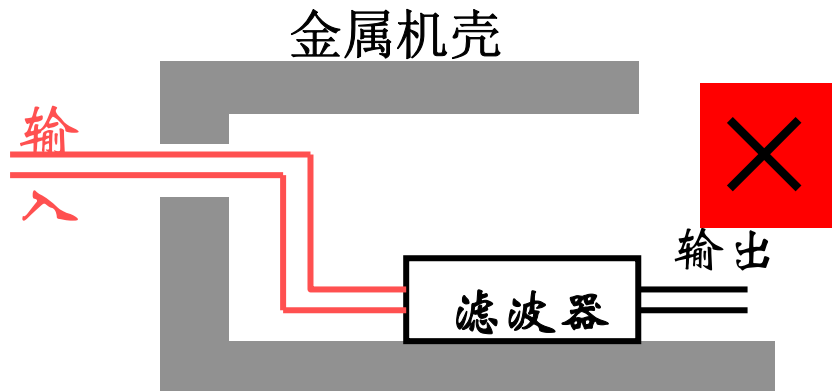
3: Carefully installment!



滤波器的输入输出引线应拉开距离，严禁并行走线和交叉走线。



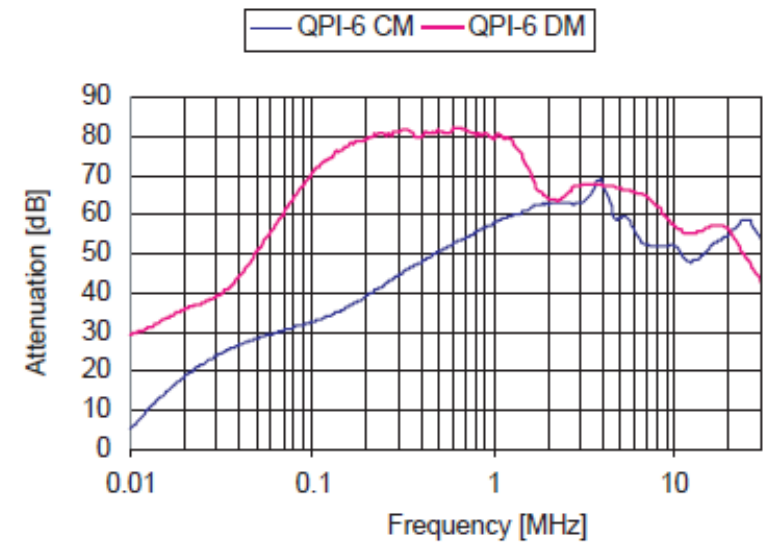
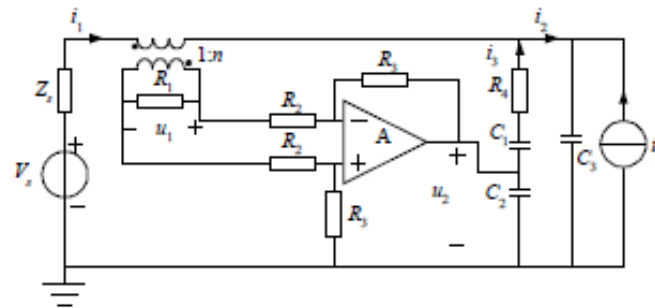
滤波器的输入、输出引线之间尽可能实现屏蔽隔离。

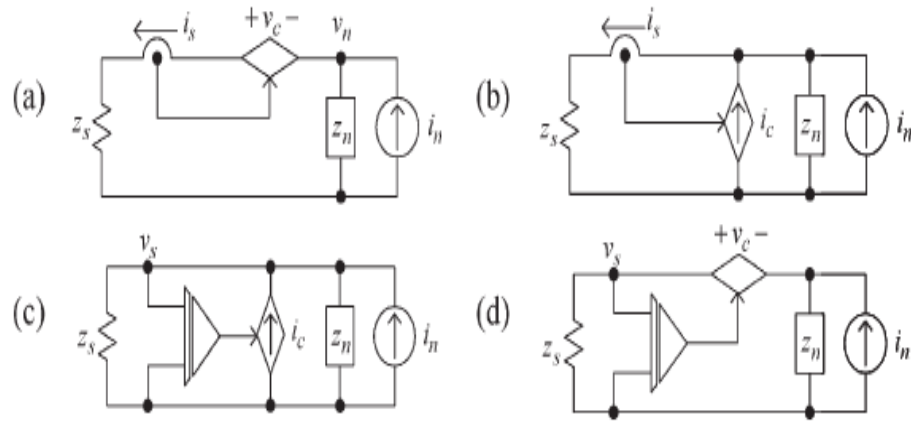


有源滤波器，可在150kHz-几MHz有效

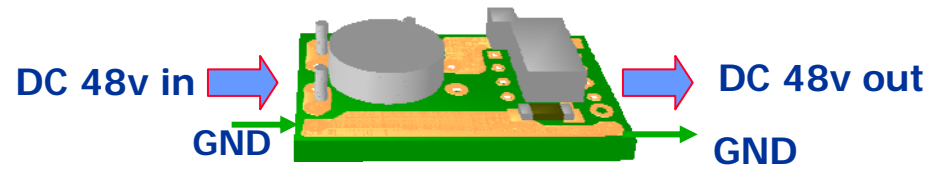


Active EMI filter for DC/DC
Picor Com





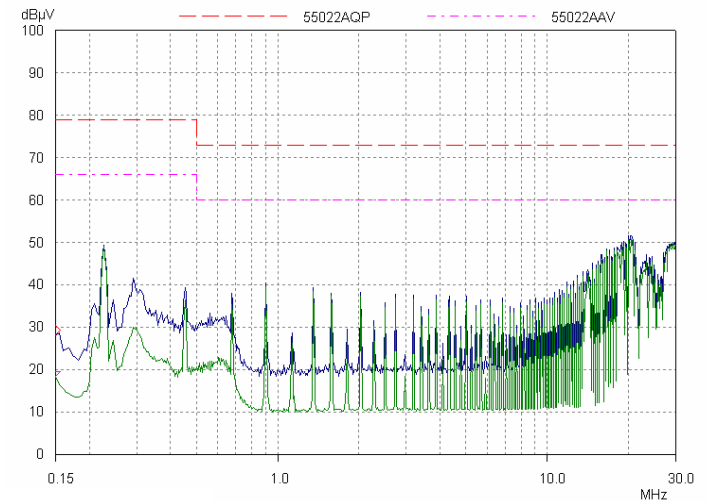
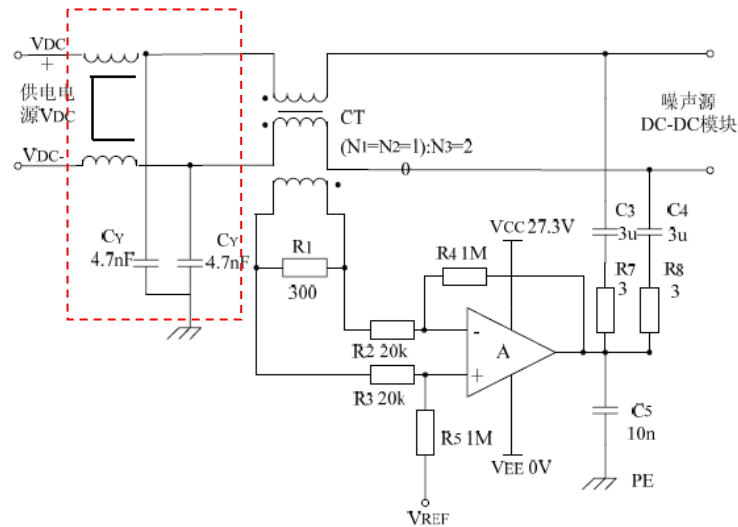
ALL active EMI filter topology



Delta/ Xjtu/



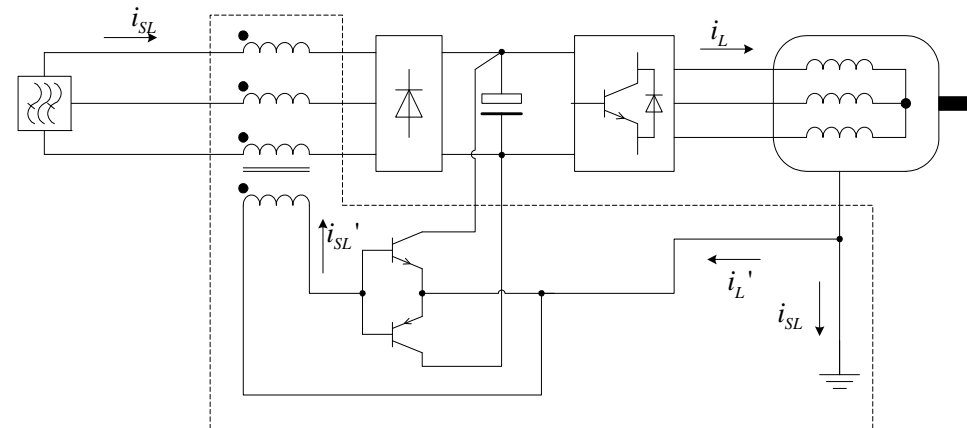
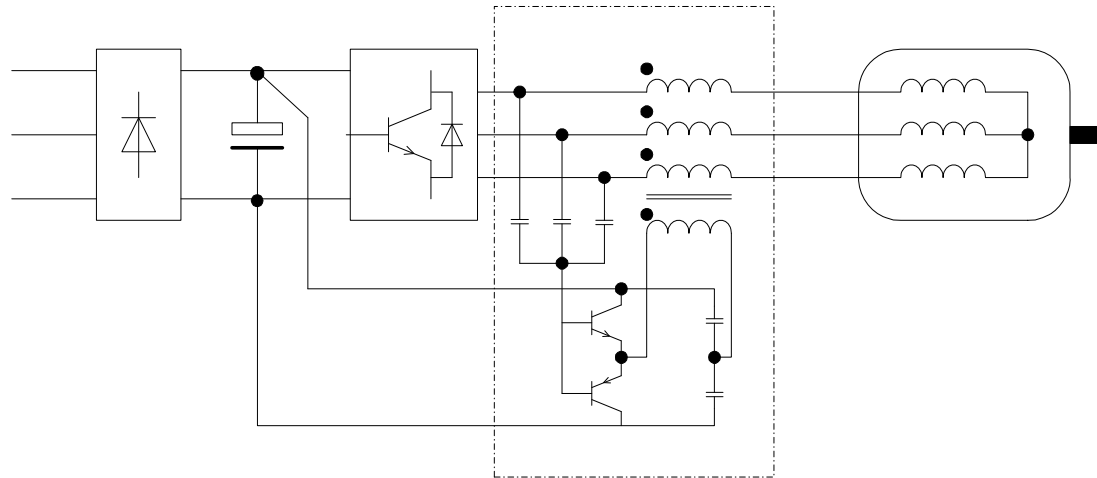
Emerson/ Hit



Hybird EMI filter

也用于逆变电源

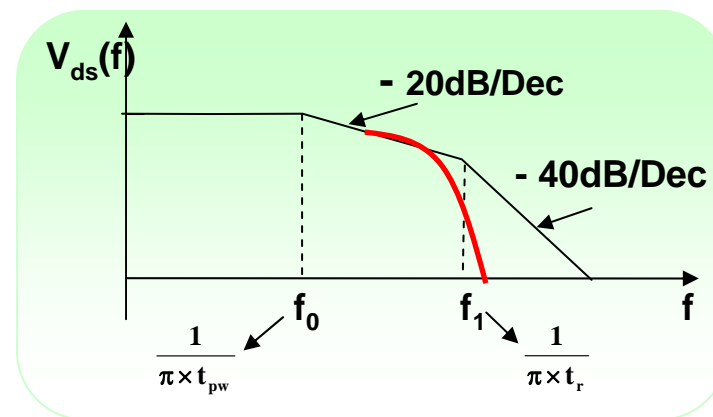
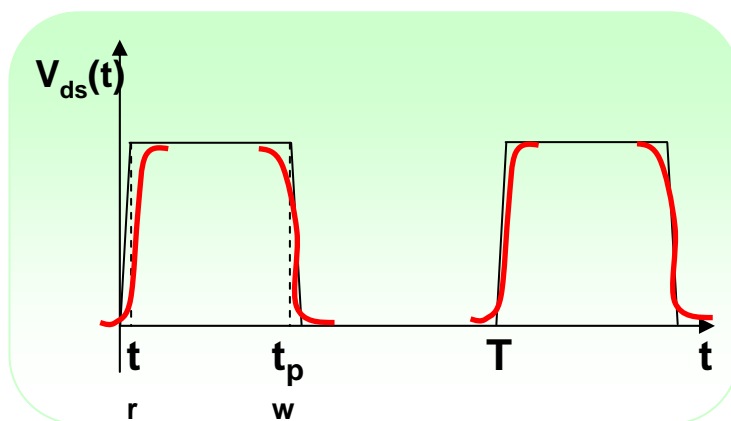
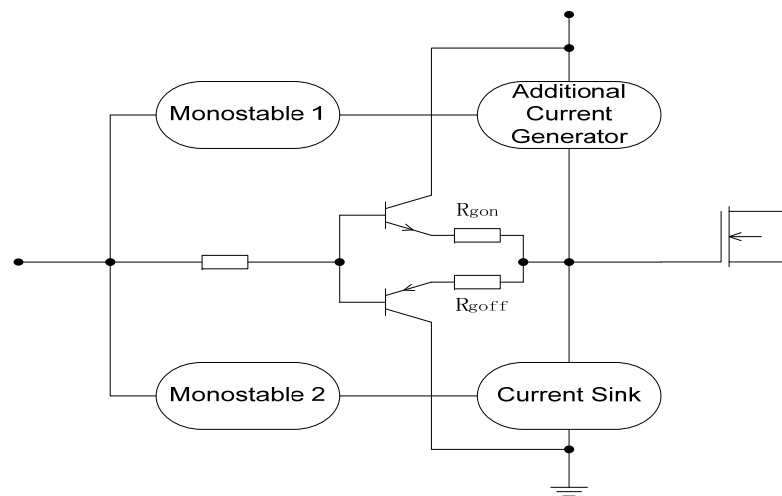
Active Common Mode Noise Canceller



Active EMI Filter

三：根据电源拓扑、结构、控制等多种方面，采用新型抑制方法

B1: 改善门极驱动

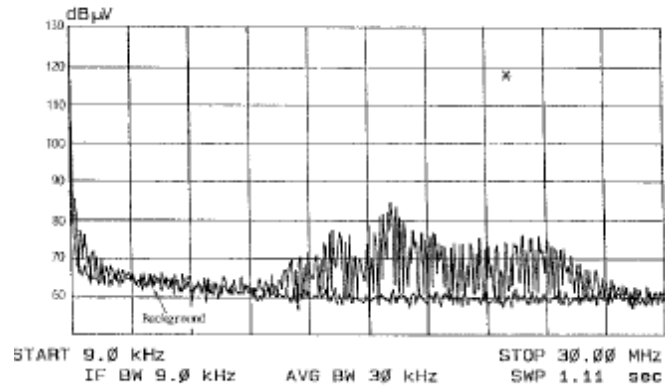


适当的驱动可使功率损耗和高频频谱得到平衡

已商业化。

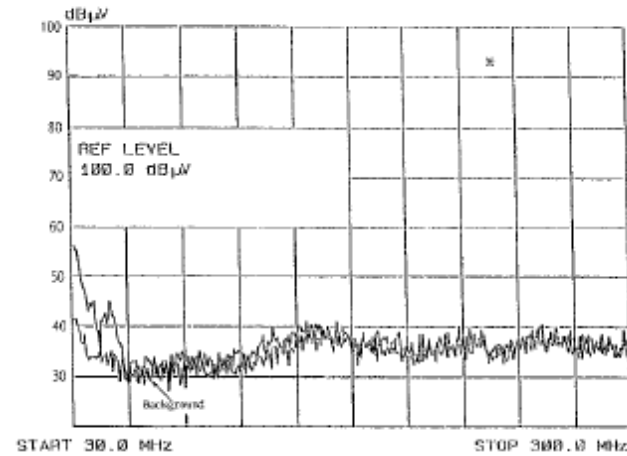
B2: 合适的软开关技术

City University of Hong Kong



传导发射

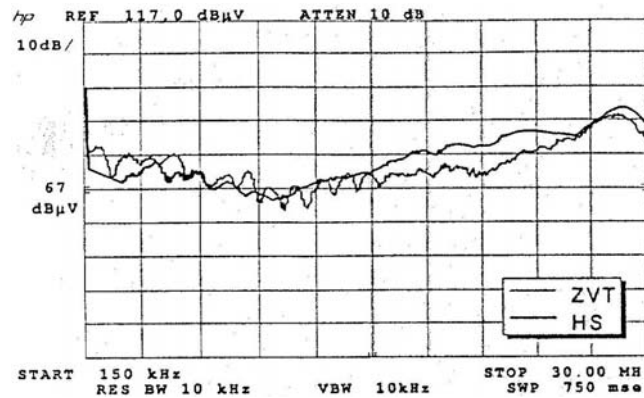
BUCK/BOOST/FLYBACK



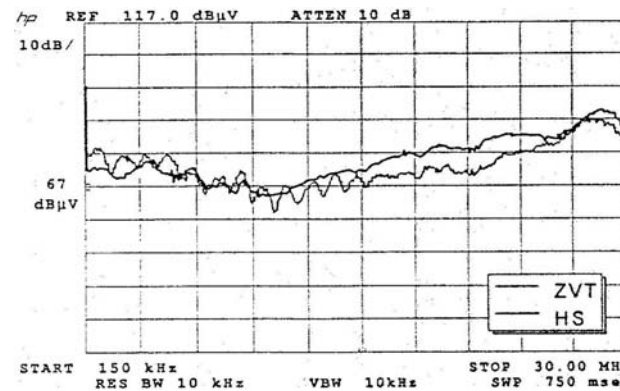
辐射发射

CPES

Hard-switching vs. soft-switching of a inverter



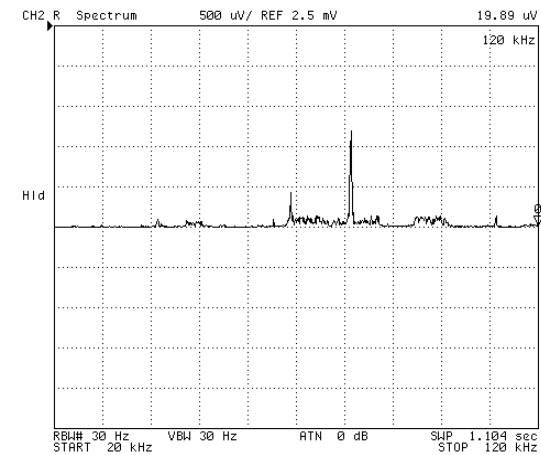
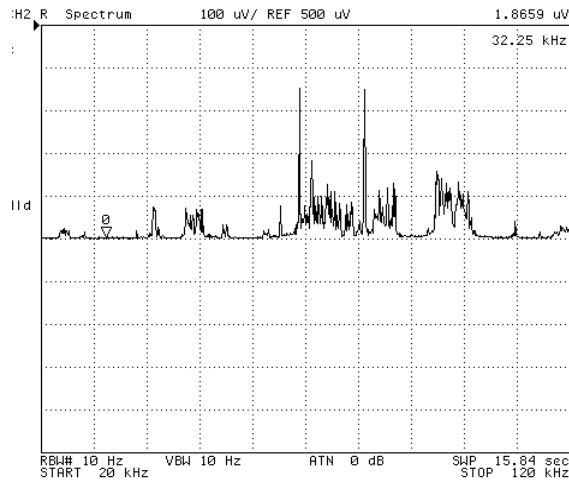
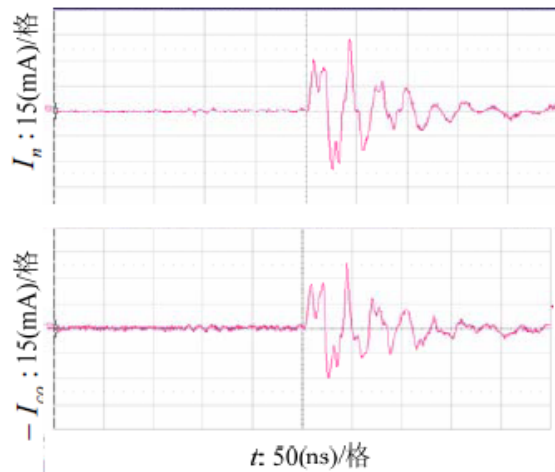
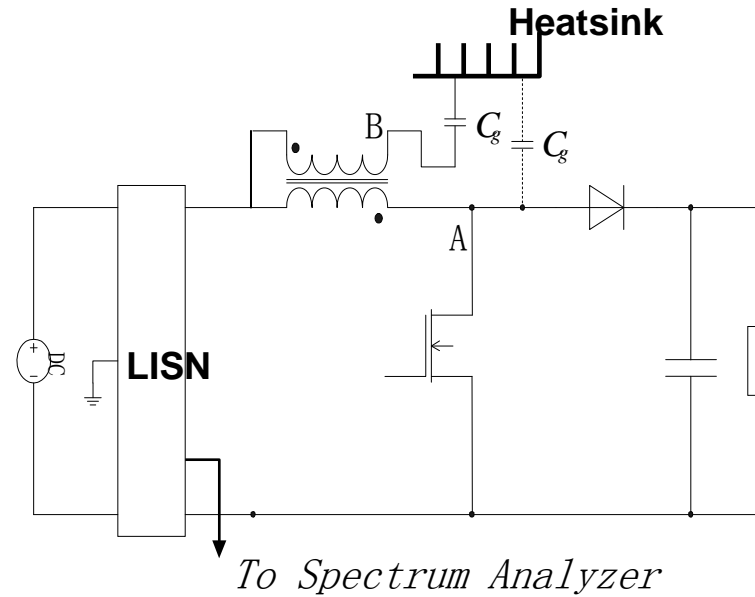
L线传导发射



N线传导发射

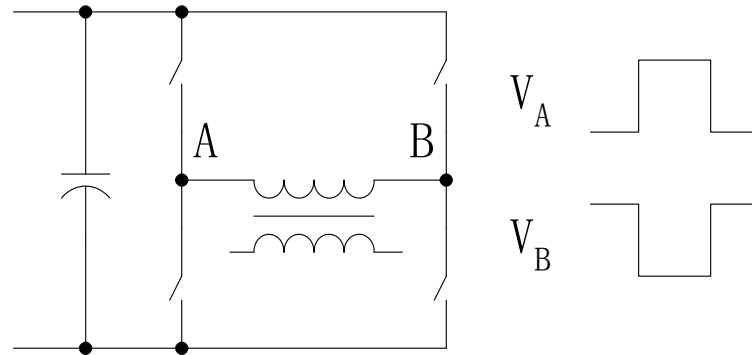
B3: 反向补偿技术

Feedback Coil in the Boost Inductor



SELECT LETTER
SPACE
BACK SPACE
ERASE TITLE
DONE
STOR DEV [DISK]
CANCEL

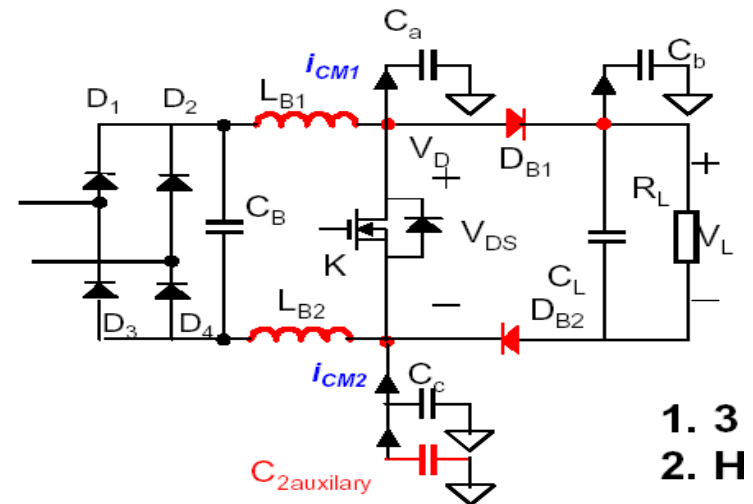
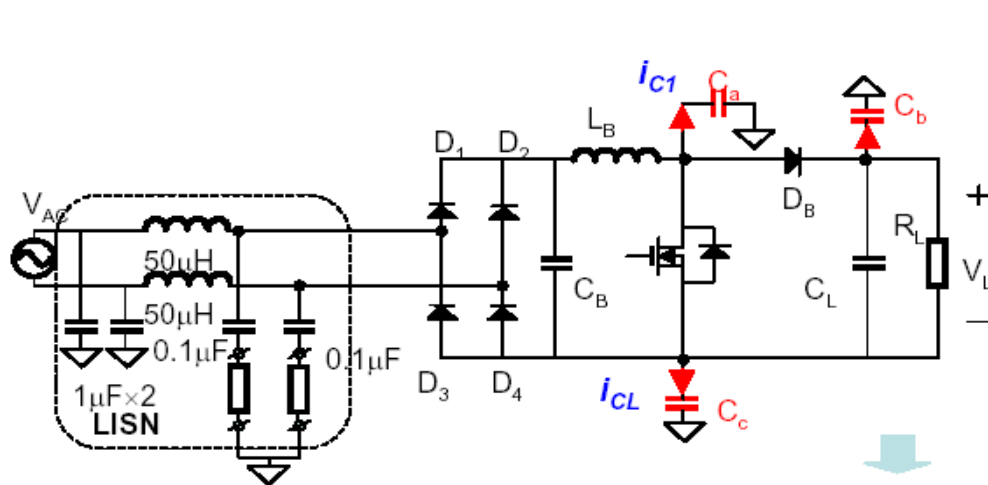
B4: 对称平衡结构 → 抑制共模发射的有效办法



ZERO CM EMISSION!

FBSP bad CM emission!!

Symmetric trigger



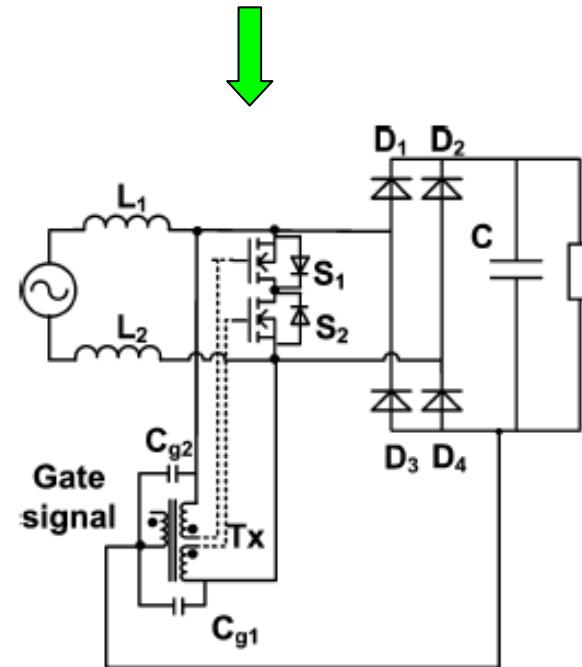
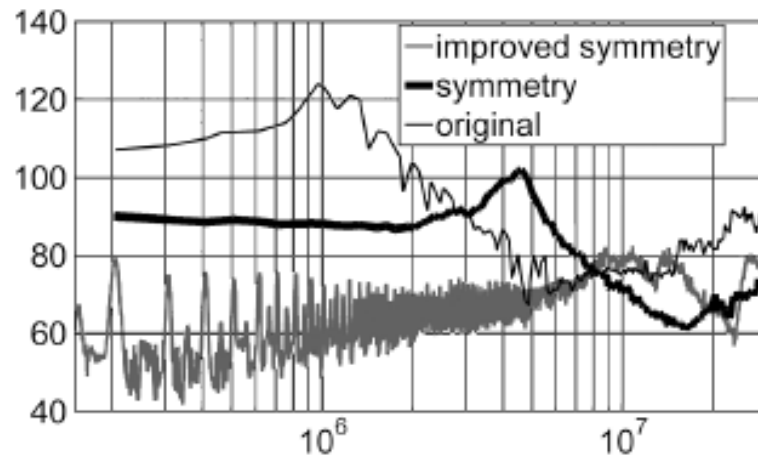
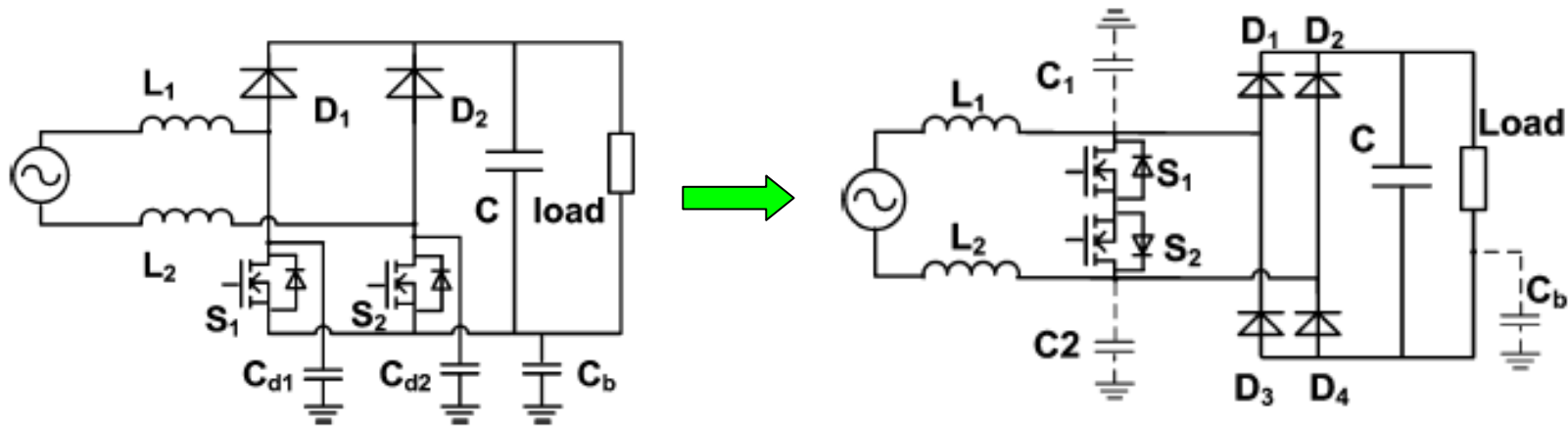
1. 3
2. H

Symmetric structure

These principle has early been proposed in 90's and it can be used in any topology.

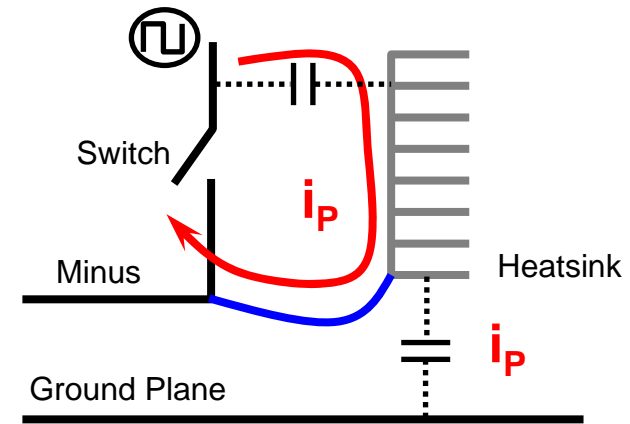
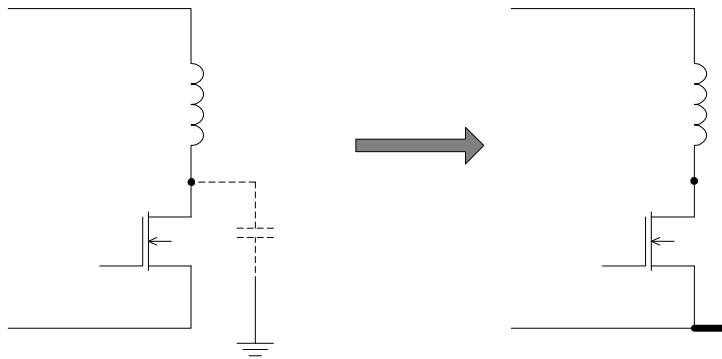
Low effectiveness, high cost!

Dual Boost: CM Emission is large.

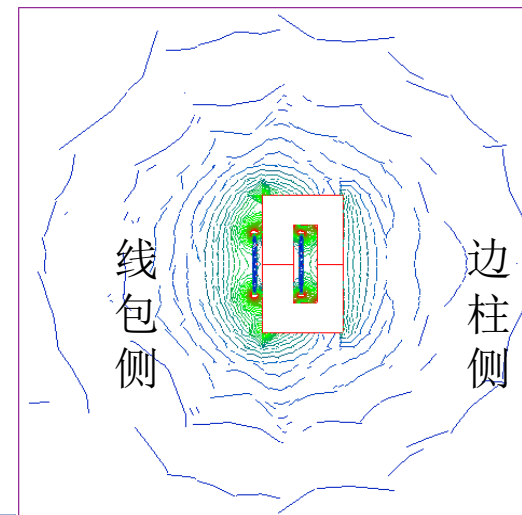


B5: 巧用屏蔽

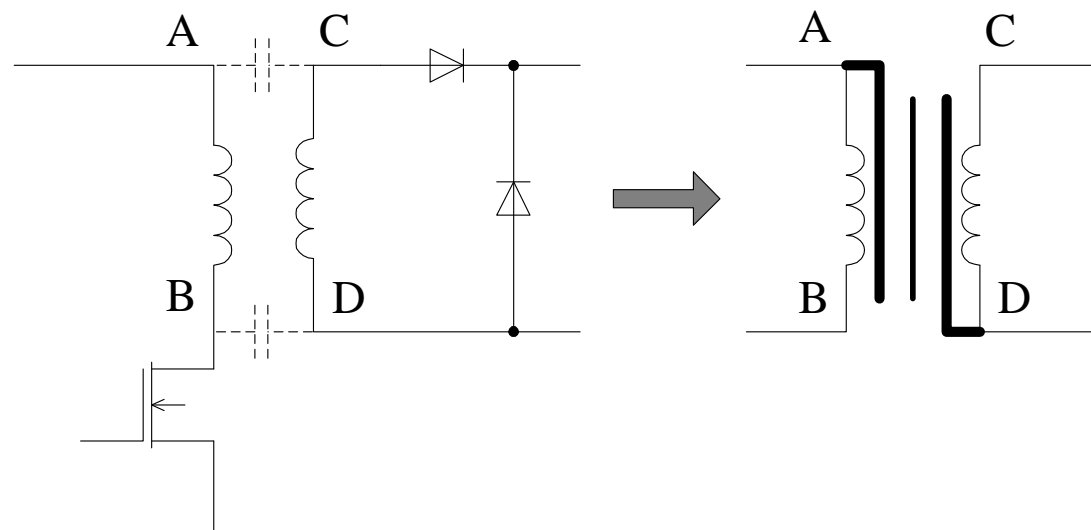
1. Heatsink Connected to the Minus bus



2. Copper Foil around X'FORM



3: Shielding primary and secondary of transformer



*Delta com: USA patent 20070171585
Method for suppressing common mode noise*

B6: 频率调制技术

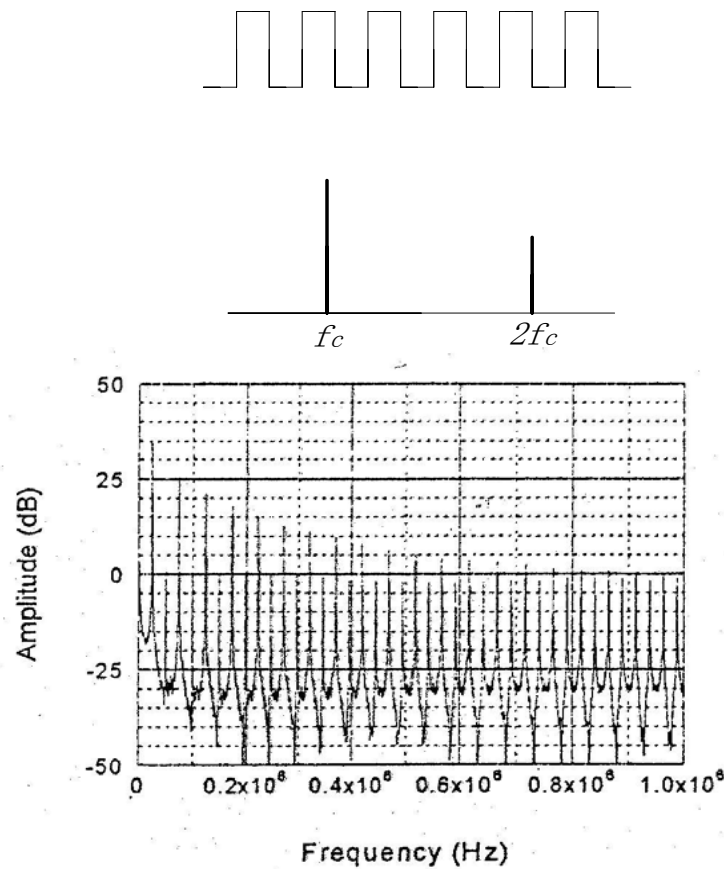


Fig 1a. Constant 25kHz PWM

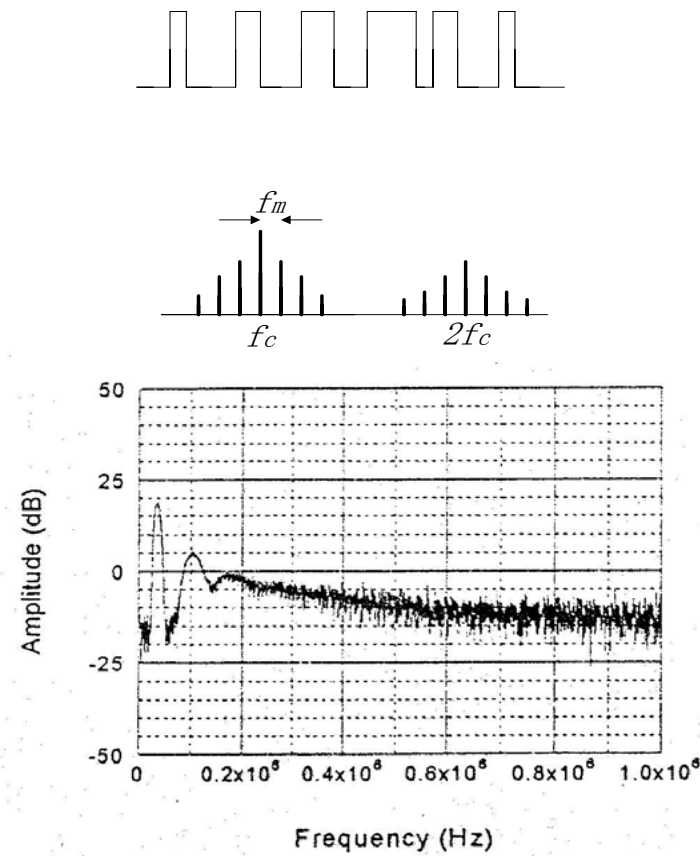
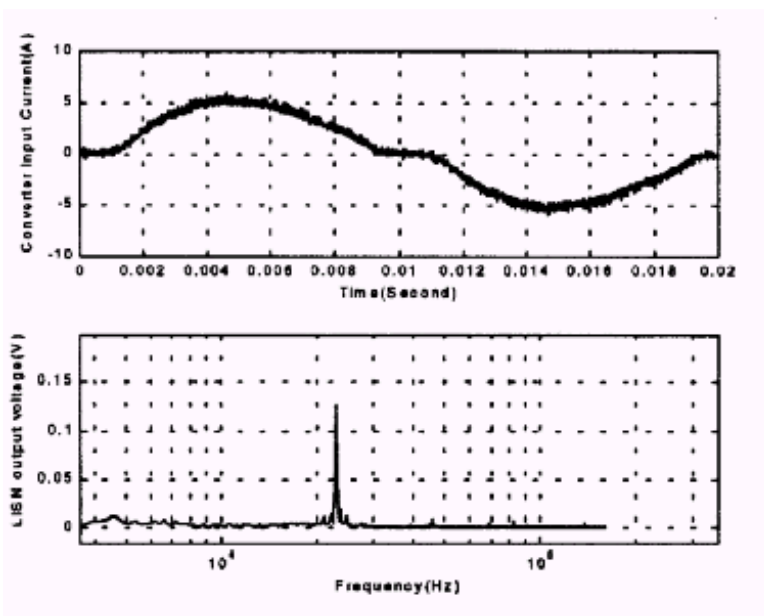


Fig 1c. $\Delta f=20\text{kHz}$ (frequency varied from 25kHz to 45kHz), $n=256$.

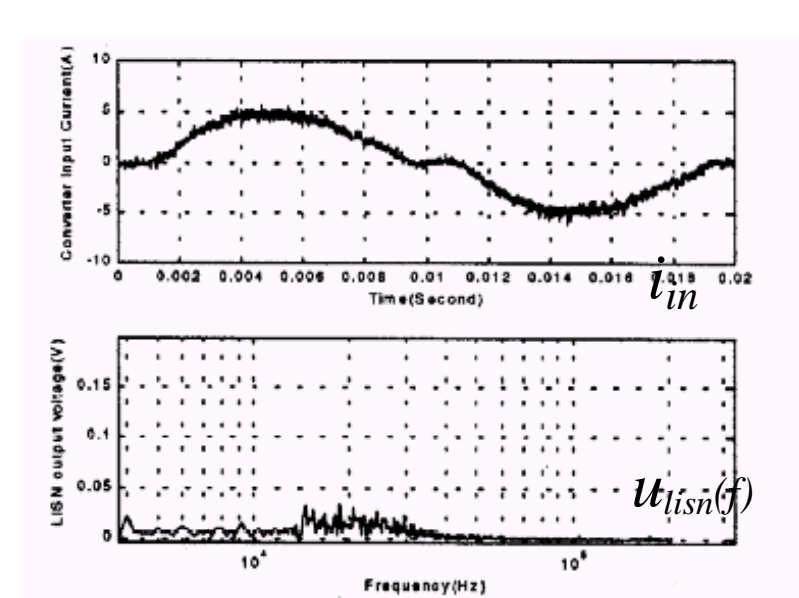
Switching frequency modulation

— proposed by F. Lin et al, IEEE PESC'93

- **Random modulation**
_____ proposed by D.A. Stone et al, IEEE APEC'96
- **Sigma - Delta modulation**
_____ proposed by J. Paramesh et al, IEEE APEC'99
- **Comparison : PWM & RPWM [43]**



PWM, $f = 25 \text{ kHz}$

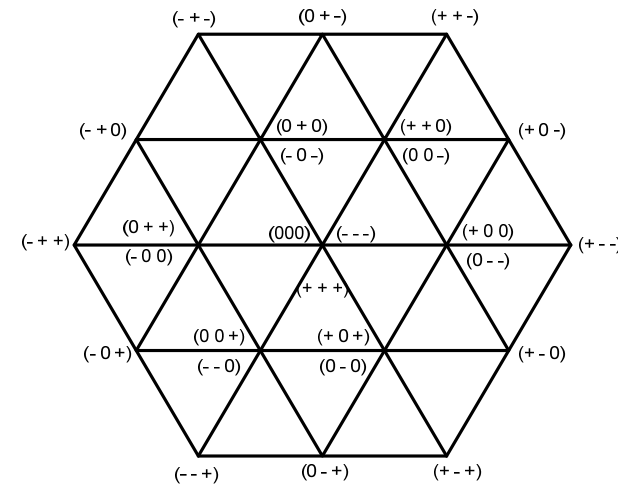
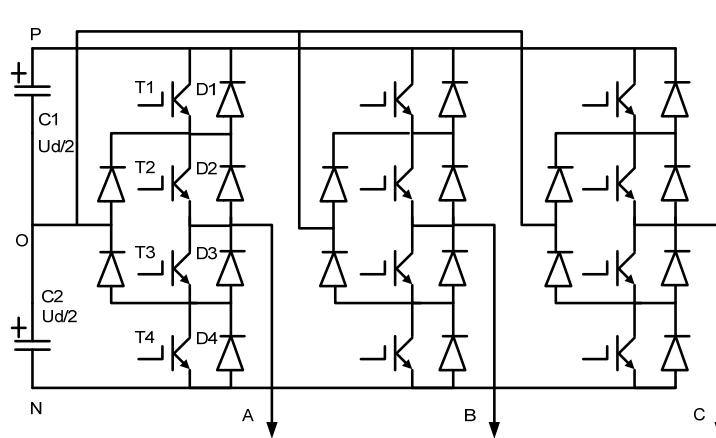


RPWM, $15 \text{ kHz} < f < 30 \text{ kHz}$

已商业化!

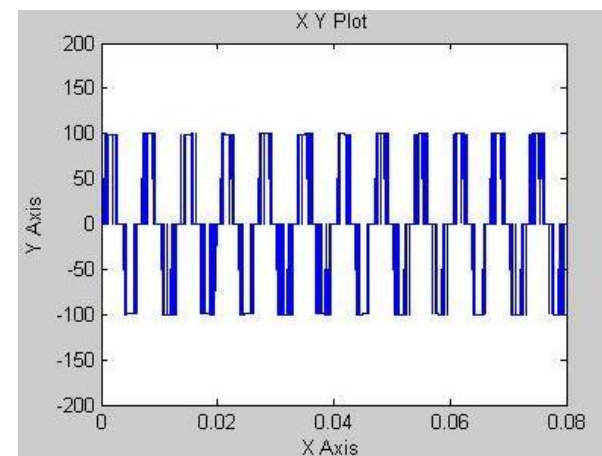
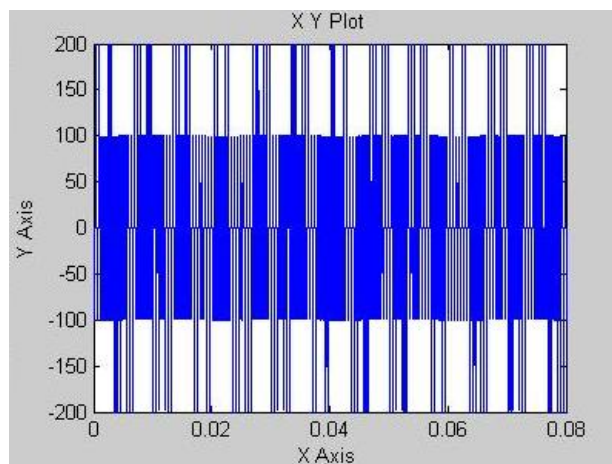
抖频幅度要大于10kHz. 输出直流有调制纹波!

B7: 合理触发控制



三电平逆变器共存在27状态, 存在 $U_a+U_b+U_c$ 小的SVPWM策略

CM Voltage 可从 $U_{bus}/3$ 降到 $U_{bus}/6$!

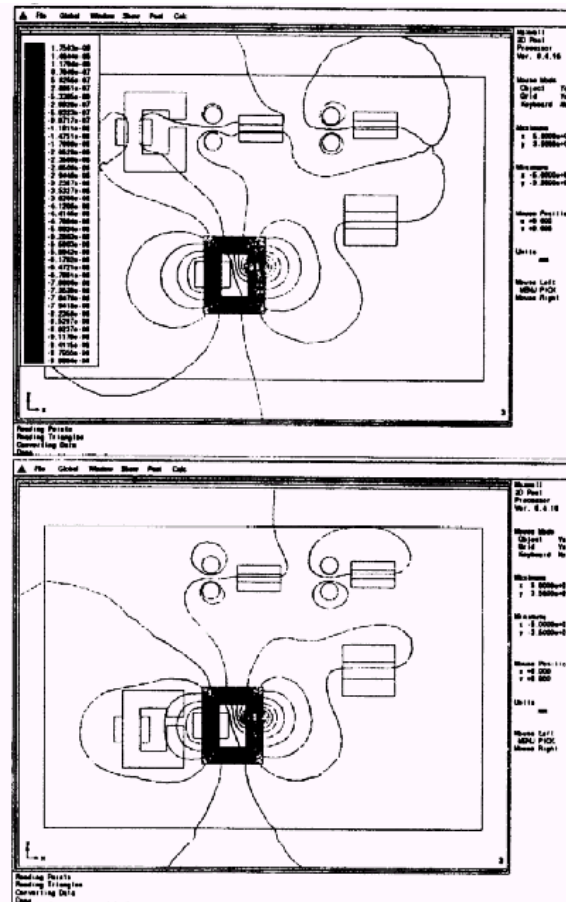


HIT for SIEMENS

B8: PCB精心设计

减小 dv/dt 导体面积, 减小 di/dt 回路面积!
敏感电路远离高 dv/dt 、 di/dt 点!

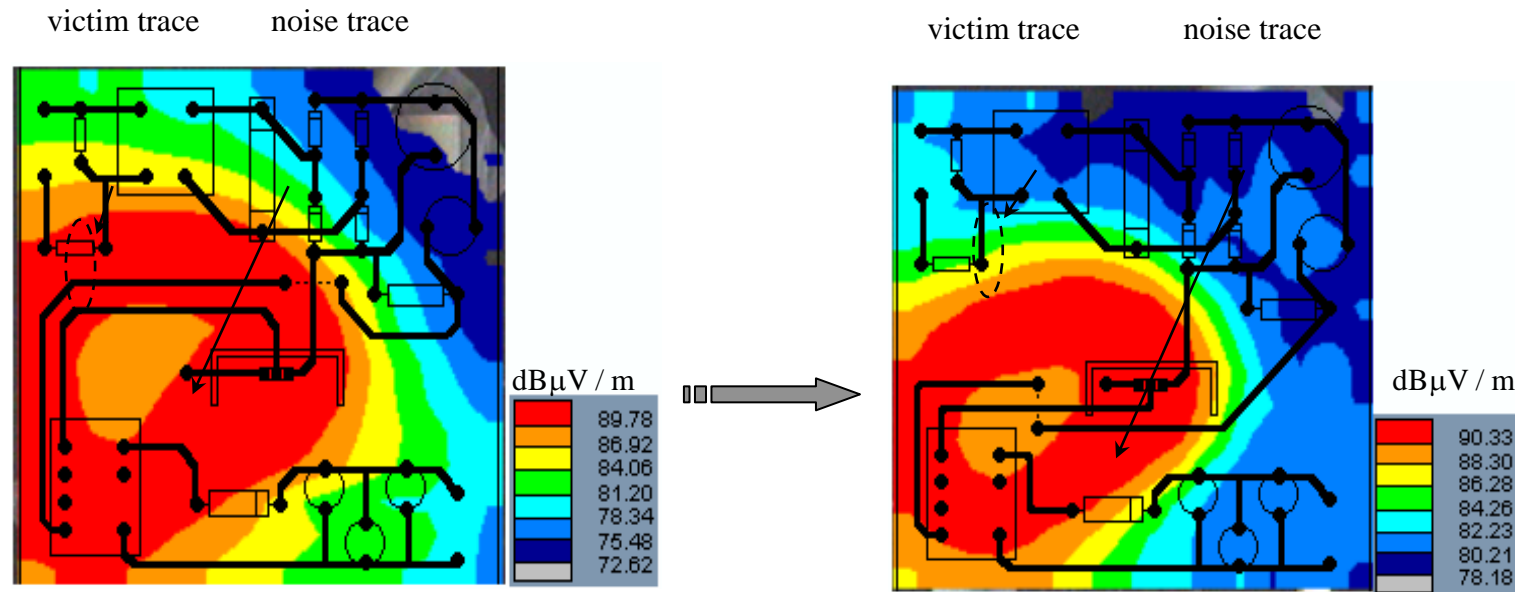
MAXWELL Software Assistant Method



(a) Flux plot of quasi-resonant boost converter with basic layout

(b) Flux plot of quasi-resonant converter with changed good layout

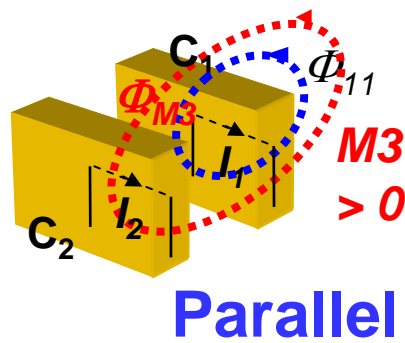
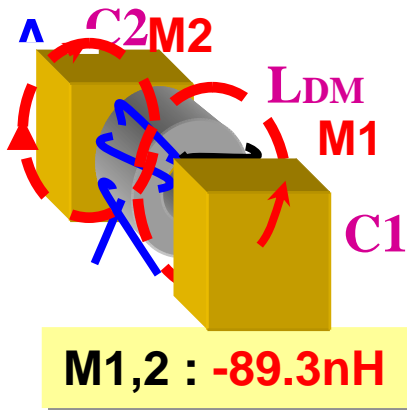
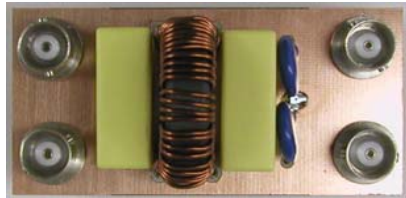
Routing Traces by Electrical Field Emission scan



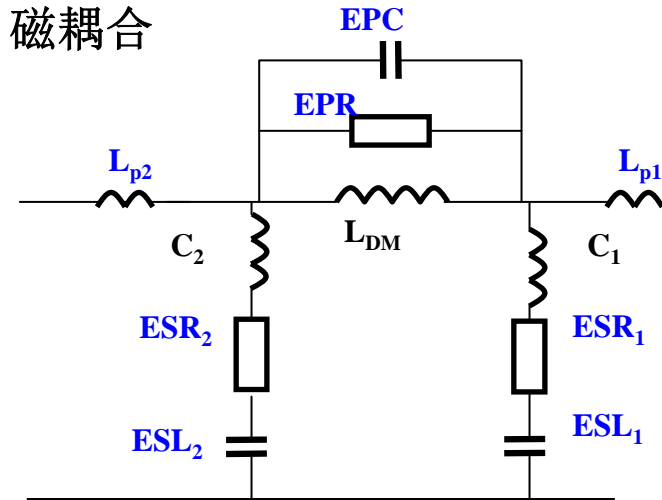
— proposed by X. Wu Zhejiang Univ, IEEE APEC'99

- The victim trace in weaker emission area is likely to pick up less noise;
- PCB designers can arrange critical trace in suitable position to receive less interference according to emission map.

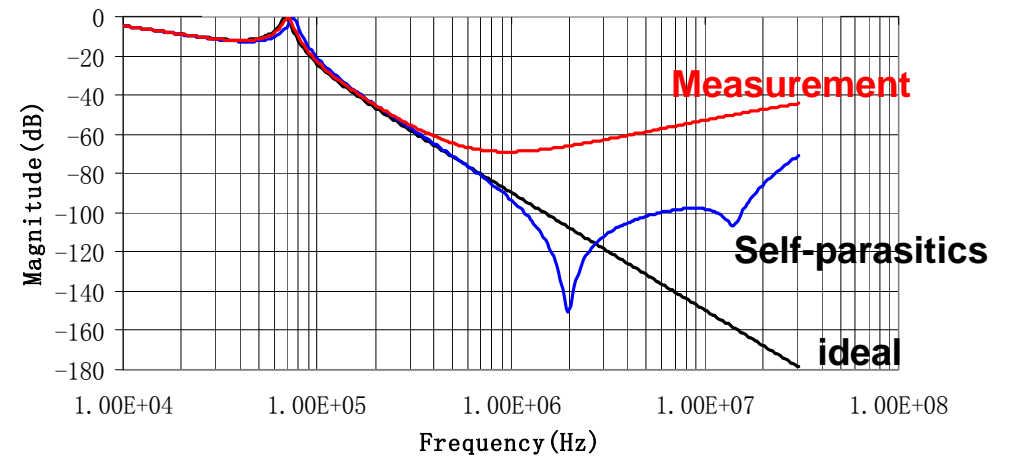
四：EMI滤波器的特殊问题

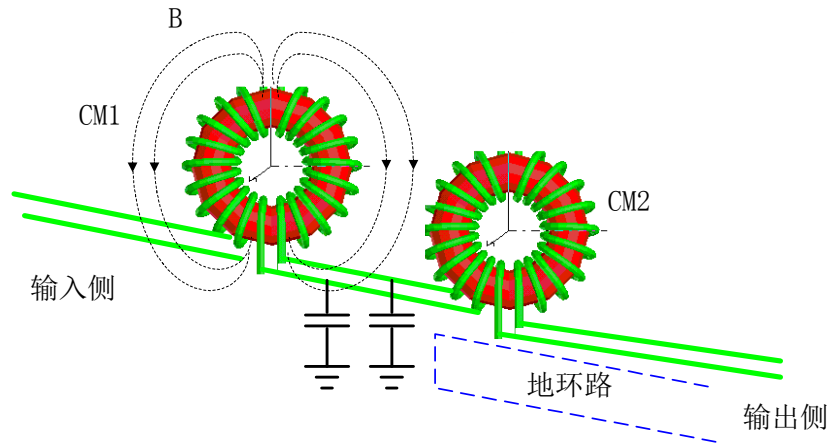


磁耦合

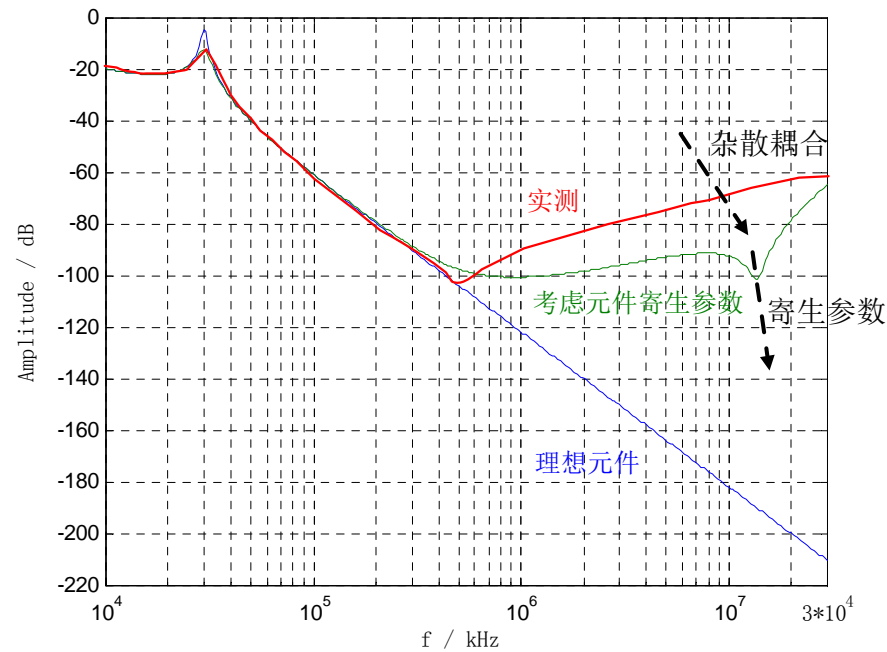
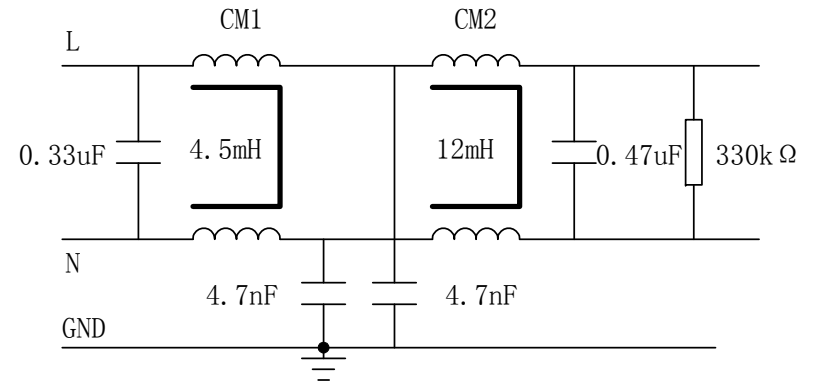


Insertion Voltage Gain

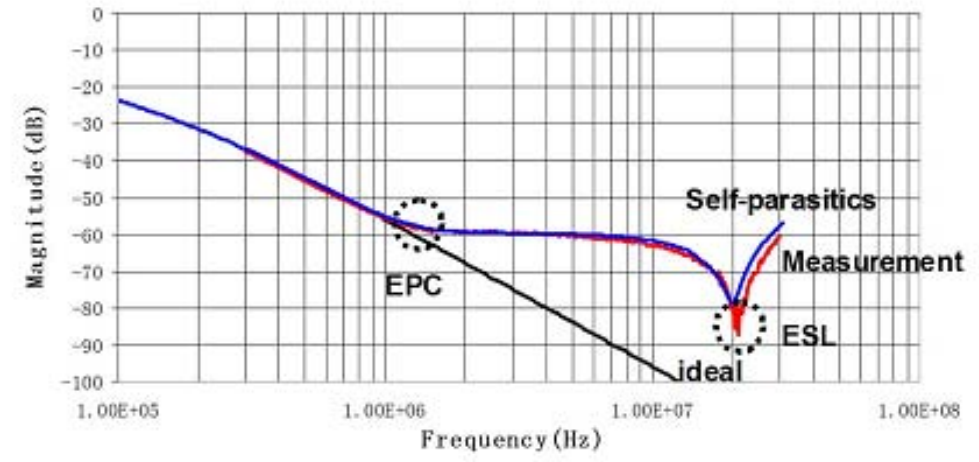
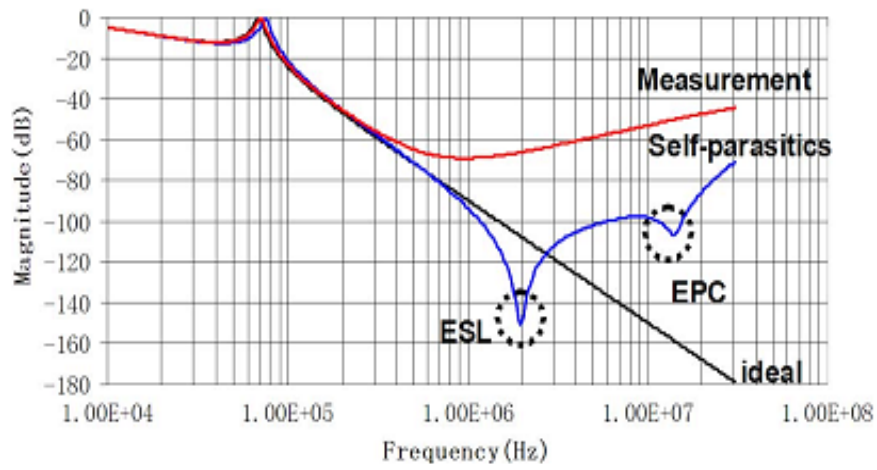
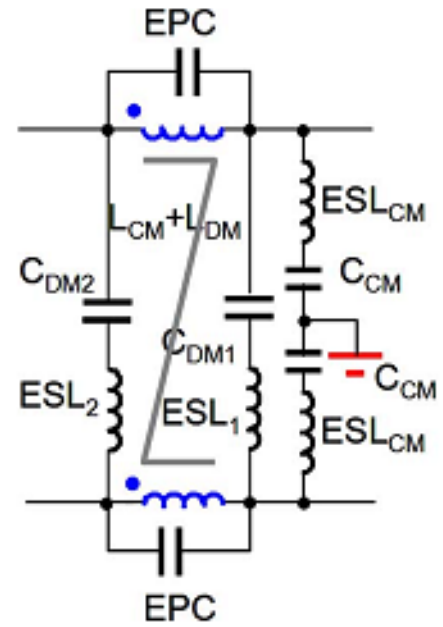
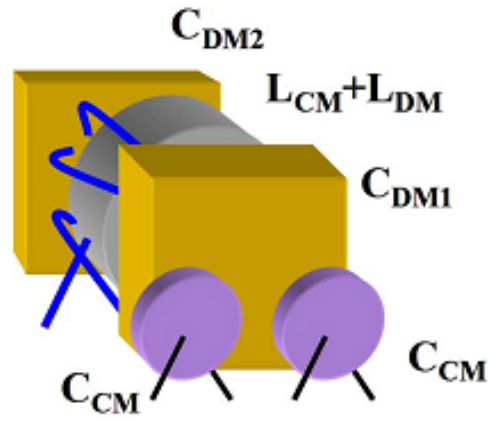


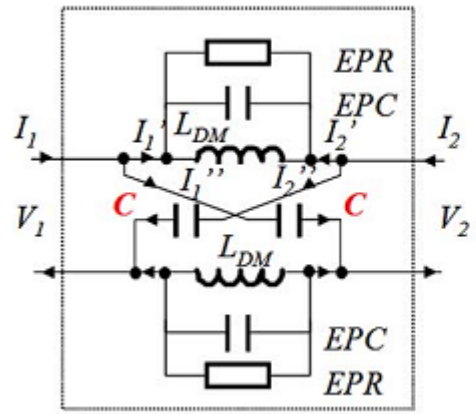


电耦合

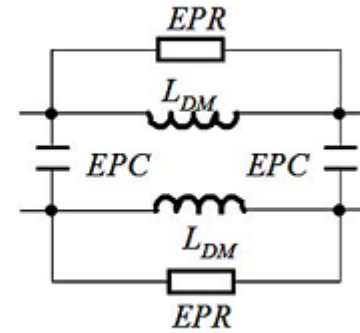


寄生参数/耦合的抑制

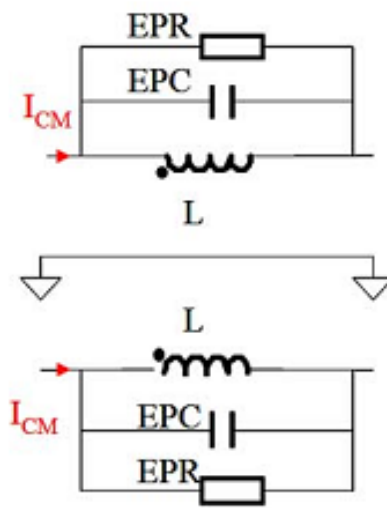
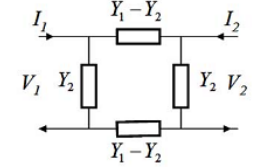
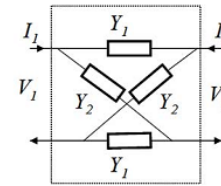




$C = EPC$

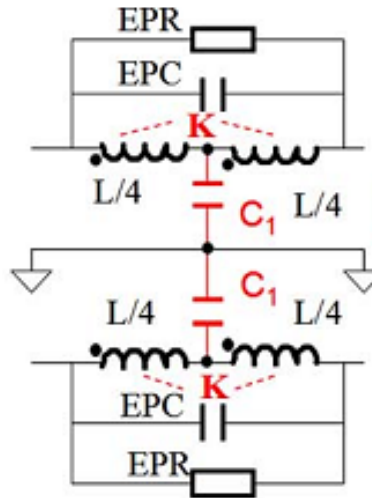


No EPC



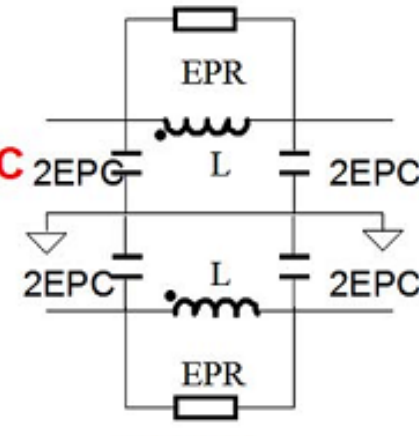
(a)

$K=1$



(b)

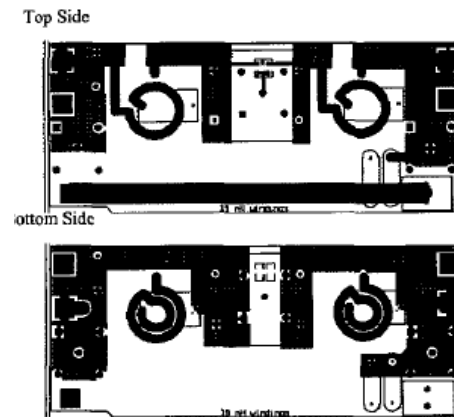
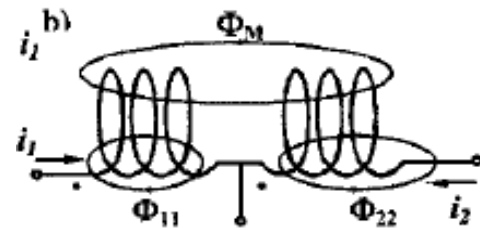
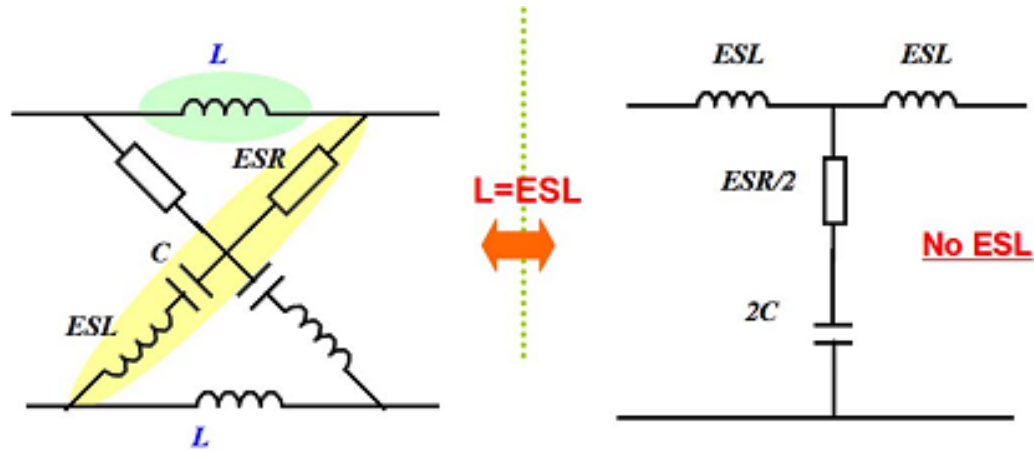
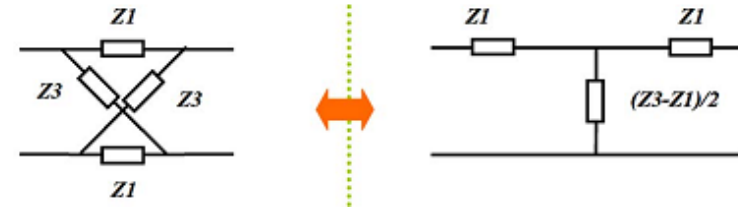
If $C_1 = 4EPC$



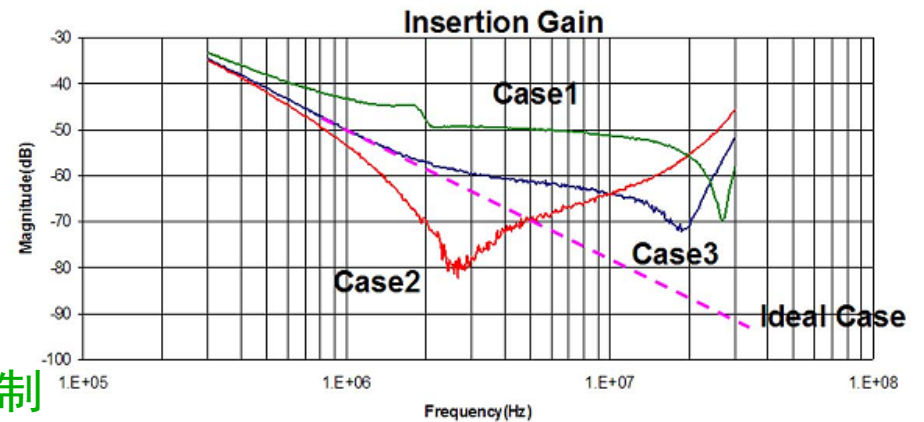
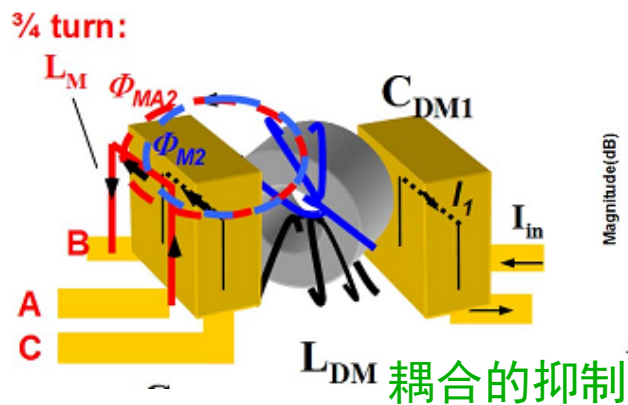
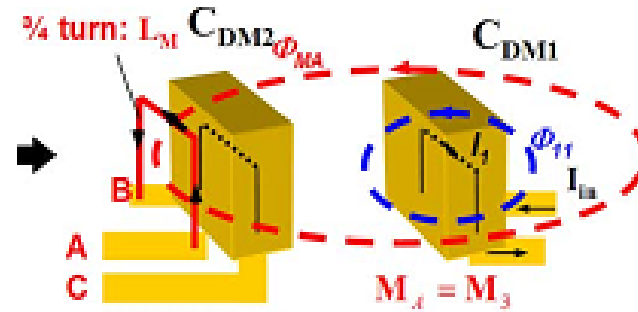
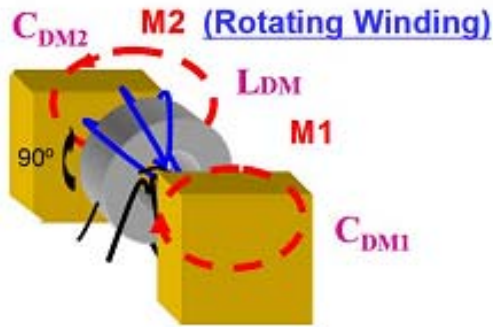
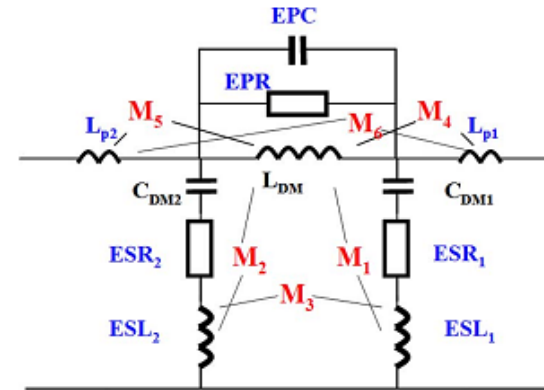
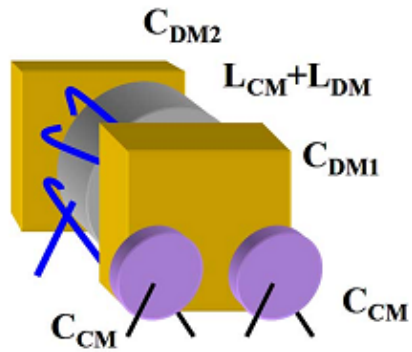
NO EPC

(c)

电感EPC的抑制



电容ESL抑制



Any questions?





Thanks for your attention!

谢谢大家!